

SEMICONDUCTOR DEVICES

Carrier Statistics

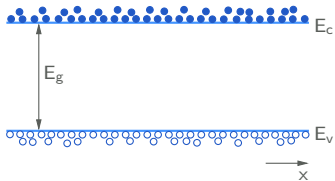


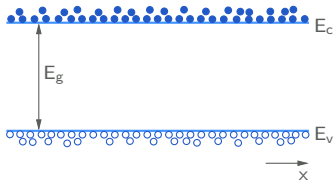
M. B. Patil

mbpatil@ee.iitb.ac.in

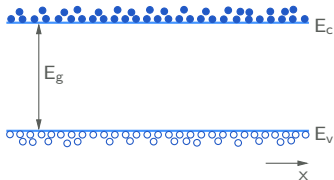
www.ee.iitb.ac.in/~sequel

Department of Electrical Engineering
Indian Institute of Technology Bombay

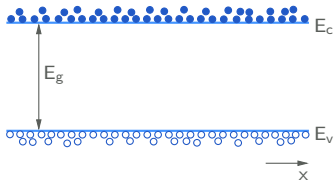




- * The term “carrier” refers to mobile entities, viz., electrons in the conduction band (or simply “electrons”) and vacancies in the valence band (or simply “holes”).

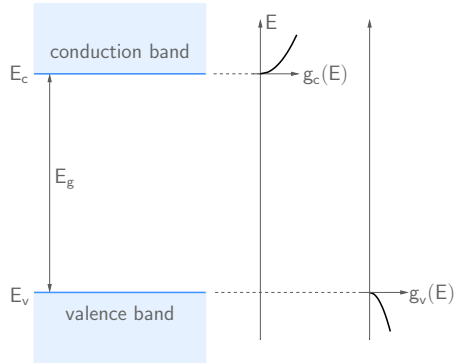


- * The term “carrier” refers to mobile entities, viz., electrons in the conduction band (or simply “electrons”) and vacancies in the valence band (or simply “holes”).
- * We are interested in the carrier densities, i.e., electron density (n) and hole density (p), because they are responsible for carrying a current. (The nuclei and core electrons of the silicon atoms do not contribute to conduction.)

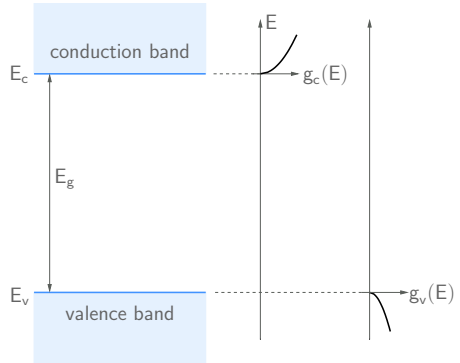


- * The term “carrier” refers to mobile entities, viz., electrons in the conduction band (or simply “electrons”) and vacancies in the valence band (or simply “holes”).
- * We are interested in the carrier densities, i.e., electron density (n) and hole density (p), because they are responsible for carrying a current. (The nuclei and core electrons of the silicon atoms do not contribute to conduction.)
- * We will first consider a semiconductor in equilibrium, i.e., without an external perturbation such as an applied voltage, a magnetic field, or optical illumination.

Electron density (n) in equilibrium

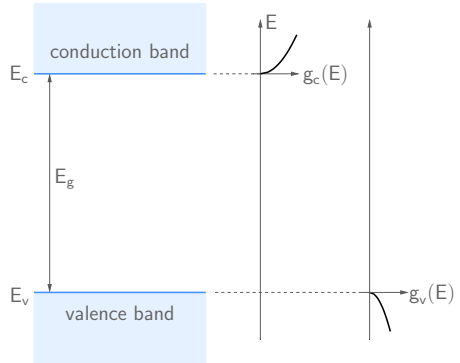


- * The electron density depends on two factors:



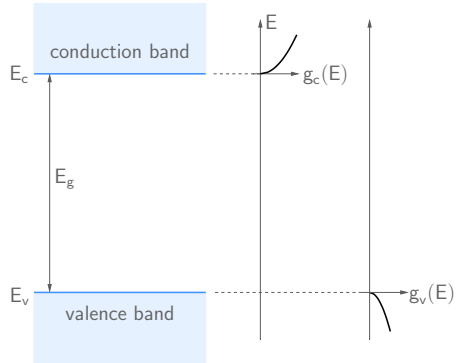
Electron density (n) in equilibrium

- * The electron density depends on two factors:
 - How many states are available in the conduction band for the electrons to occupy?



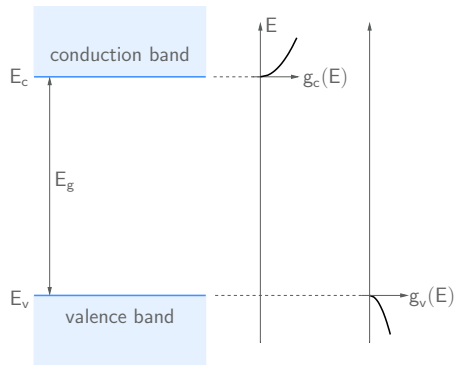
Electron density (n) in equilibrium

- * The electron density depends on two factors:
 - How many states are available in the conduction band for the electrons to occupy?
 - What is the probability that a given state (at energy E) is occupied?



Electron density (n) in equilibrium

- * The electron density depends on two factors:
 - How many states are available in the conduction band for the electrons to occupy?
 - What is the probability that a given state (at energy E) is occupied?
- * The “density of states” function $g_c(E)$ gives the number of states available per unit energy per unit volume.



Electron density (n) in equilibrium

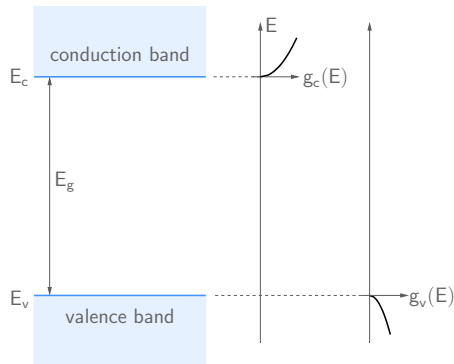
- * The electron density depends on two factors:
 - How many states are available in the conduction band for the electrons to occupy?
 - What is the probability that a given state (at energy E) is occupied?
- * The “density of states” function $g_c(E)$ gives the number of states available per unit energy per unit volume.

$$g_c(E) = \frac{(m_n^*)^{3/2} \sqrt{2(E - E_c)}}{\pi^2 \hbar^3}, \quad E > E_c, \text{ where}$$

$m_n^* \equiv$ electron effective mass = $1.18 m_0$ for silicon at $T = 300$ K,

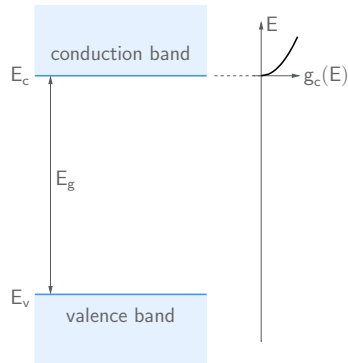
$m_0 =$ free electron mass = 9.1×10^{-31} Kg,

$\hbar = h/2\pi$, with h (Planck constant) = 6.63×10^{-34} J-s.



Electron density (n) in equilibrium

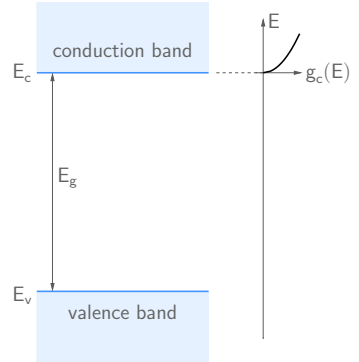
Calculate the number of states N' between E_c and $E_c + 50 \text{ meV}$ for silicon at $T = 300 \text{ K}$.



Electron density (n) in equilibrium

Calculate the number of states N' between E_c and $E_c + 50 \text{ meV}$ for silicon at $T = 300 \text{ K}$.

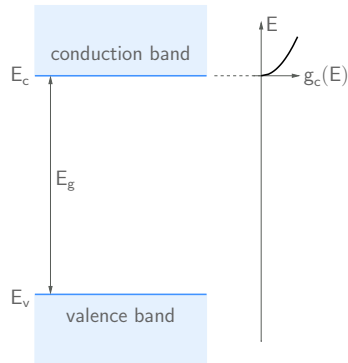
$$N' = \int_{E_c}^{E_c + \Delta E} \frac{(m_n^*)^{3/2} \sqrt{2(E - E_c)}}{\pi^2 \hbar^3} dE$$



Electron density (n) in equilibrium

Calculate the number of states N' between E_c and $E_c + 50 \text{ meV}$ for silicon at $T = 300 \text{ K}$.

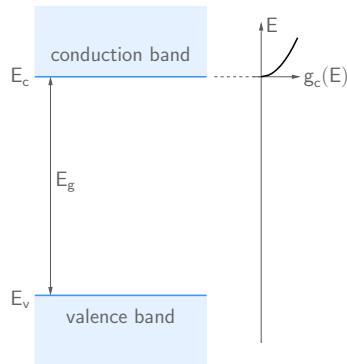
$$\begin{aligned} N' &= \int_{E_c}^{E_c + \Delta E} \frac{(m_n^*)^{3/2} \sqrt{2(E - E_c)}}{\pi^2 \hbar^3} dE \\ &= \frac{\sqrt{2} (m_n^*)^{3/2}}{\pi^2 \hbar^3} \frac{(\Delta E)^{3/2}}{3/2} \end{aligned}$$



Electron density (n) in equilibrium

Calculate the number of states N' between E_c and $E_c + 50 \text{ meV}$ for silicon at $T = 300 \text{ K}$.

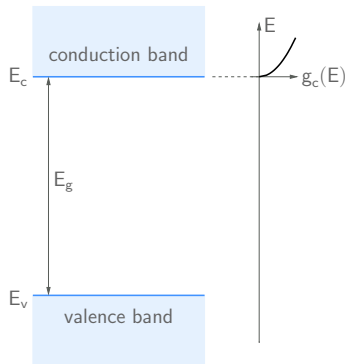
$$\begin{aligned} N' &= \int_{E_c}^{E_c + \Delta E} \frac{(m_n^*)^{3/2} \sqrt{2(E - E_c)}}{\pi^2 \hbar^3} dE \\ &= \frac{\sqrt{2} (m_n^*)^{3/2}}{\pi^2 \hbar^3} \frac{(\Delta E)^{3/2}}{3/2} \\ &= \frac{16\sqrt{2} \pi}{3} \left(\frac{m_n^* \Delta E}{h^2} \right)^{3/2} \end{aligned}$$



Electron density (n) in equilibrium

Calculate the number of states N' between E_c and $E_c + 50 \text{ meV}$ for silicon at $T = 300 \text{ K}$.

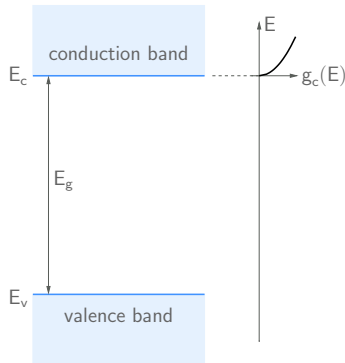
$$\begin{aligned} N' &= \int_{E_c}^{E_c + \Delta E} \frac{(m_n^*)^{3/2} \sqrt{2(E - E_c)}}{\pi^2 \hbar^3} dE \\ &= \frac{\sqrt{2} (m_n^*)^{3/2}}{\pi^2 \hbar^3} \frac{(\Delta E)^{3/2}}{3/2} \\ &= \frac{16\sqrt{2}\pi}{3} \left(\frac{m_n^* \Delta E}{h^2} \right)^{3/2} \\ &= 23.7 \times \left[\frac{1.18 \times 9.1 \times 10^{-31} \times 50 \times 10^{-3} \times 1.6 \times 10^{-19}}{(6.63 \times 10^{-34})^2} \right]^{3/2} \end{aligned}$$



Electron density (n) in equilibrium

Calculate the number of states N' between E_c and $E_c + 50 \text{ meV}$ for silicon at $T = 300 \text{ K}$.

$$\begin{aligned} N' &= \int_{E_c}^{E_c + \Delta E} \frac{(m_n^*)^{3/2} \sqrt{2(E - E_c)}}{\pi^2 \hbar^3} dE \\ &= \frac{\sqrt{2} (m_n^*)^{3/2}}{\pi^2 \hbar^3} \frac{(\Delta E)^{3/2}}{3/2} \\ &= \frac{16\sqrt{2}\pi}{3} \left(\frac{m_n^* \Delta E}{h^2} \right)^{3/2} \\ &= 23.7 \times \left[\frac{1.18 \times 9.1 \times 10^{-31} \times 50 \times 10^{-3} \times 1.6 \times 10^{-19}}{(6.63 \times 10^{-34})^2} \right]^{3/2} \\ &= 23.7 \times 2.73 \times 10^{24} / \text{m}^3 = 6.5 \times 10^{19} / \text{cm}^3. \end{aligned}$$

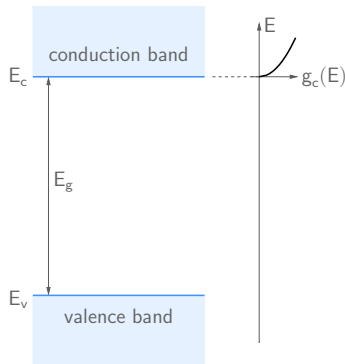


Electron density (n) in equilibrium

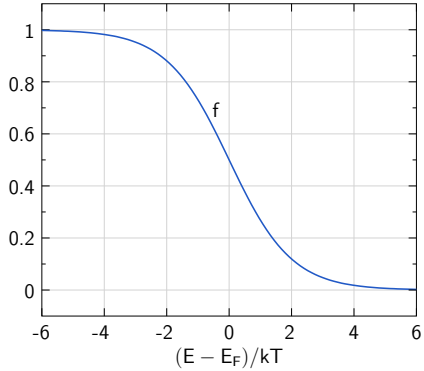
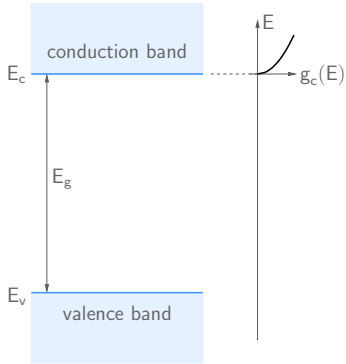
Calculate the number of states N' between E_c and $E_c + 50$ meV for silicon at $T = 300$ K.

$$\begin{aligned} N' &= \int_{E_c}^{E_c + \Delta E} \frac{(m_n^*)^{3/2} \sqrt{2(E - E_c)}}{\pi^2 \hbar^3} dE \\ &= \frac{\sqrt{2} (m_n^*)^{3/2}}{\pi^2 \hbar^3} \frac{(\Delta E)^{3/2}}{3/2} \\ &= \frac{16\sqrt{2}\pi}{3} \left(\frac{m_n^* \Delta E}{h^2} \right)^{3/2} \\ &= 23.7 \times \left[\frac{1.18 \times 9.1 \times 10^{-31} \times 50 \times 10^{-3} \times 1.6 \times 10^{-19}}{(6.63 \times 10^{-34})^2} \right]^{3/2} \\ &= 23.7 \times 2.73 \times 10^{24} / \text{m}^3 = 6.5 \times 10^{19} / \text{cm}^3. \end{aligned}$$

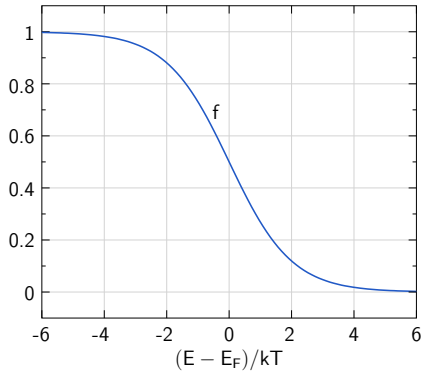
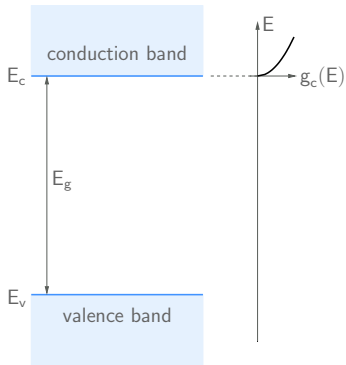
N' would be the number of electrons per unit volume (in the conduction band) if the states in the range $E_c < E < E_c + \Delta E$ were *all* occupied (and the rest of the states unoccupied). The real picture is different.



Electron density (n) in equilibrium

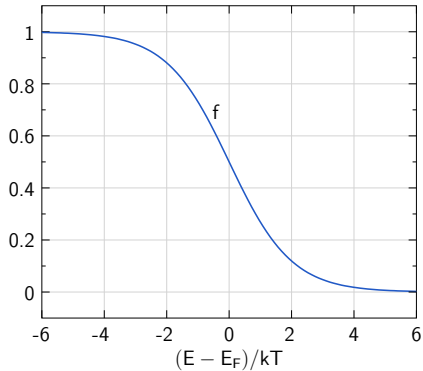
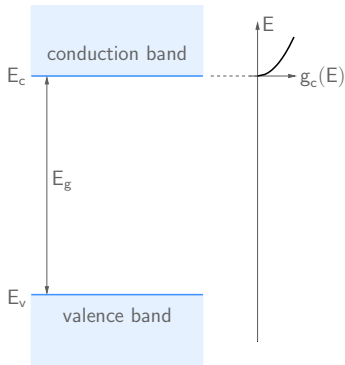


Electron density (n) in equilibrium



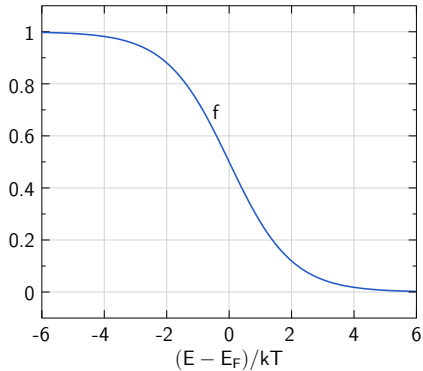
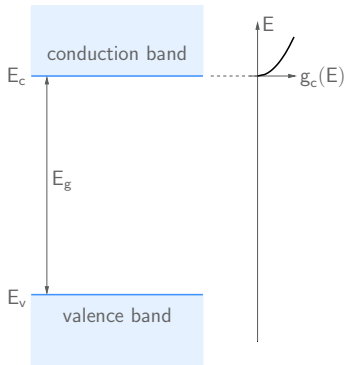
* The number of electrons in the interval E to $(E + dE)$ is not $g_c(E)dE$ but $g_c(E)f(E)dE$.

Electron density (n) in equilibrium



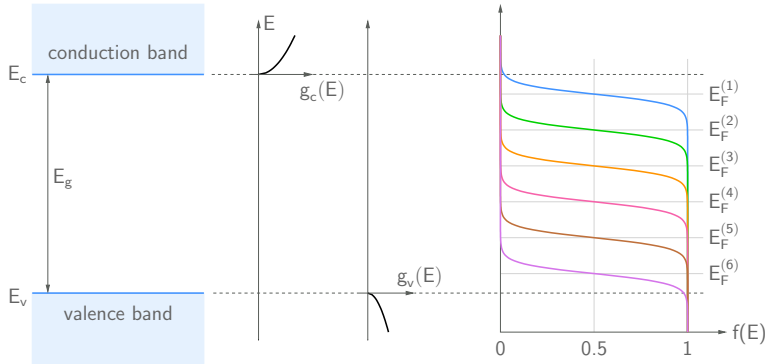
- * The number of electrons in the interval E to $(E + dE)$ is not $g_c(E)dE$ but $g_c(E)f(E)dE$.
- * $f(E)$ is the probability that the state at E is occupied.

Electron density (n) in equilibrium

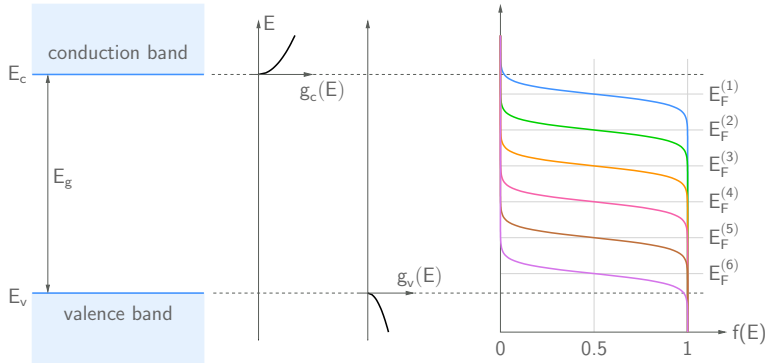


- * The number of electrons in the interval E to $(E + dE)$ is not $g_c(E)dE$ but $g_c(E)f(E)dE$.
- * $f(E)$ is the probability that the state at E is occupied.
- * The probability depends on the “Fermi level” E_F which typically lies in the forbidden gap.

Electron density (n) in equilibrium

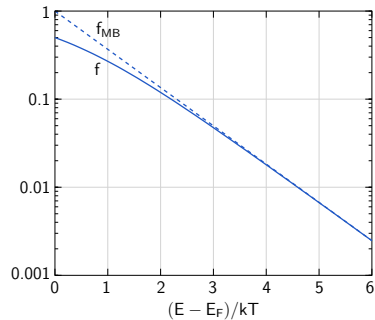
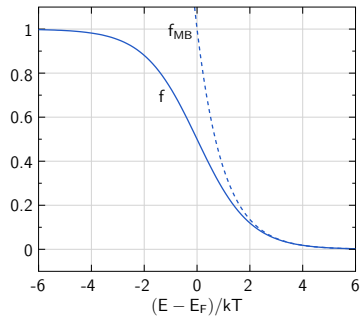
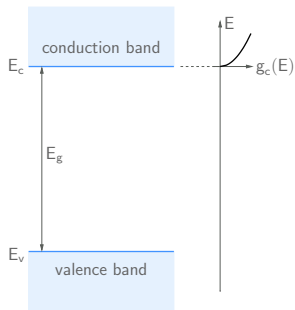


Electron density (n) in equilibrium

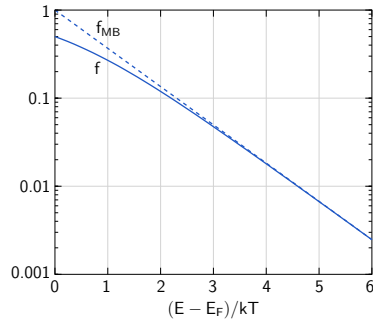
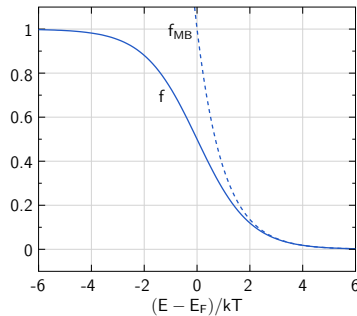
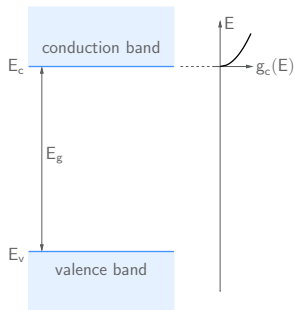


- * A change in the Fermi level causes the probability function to shift, and therefore the carrier concentrations (n and p) change substantially with E_F .

Electron density (n) in equilibrium

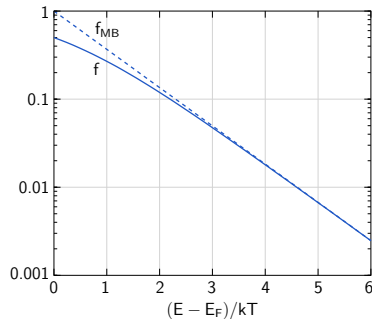
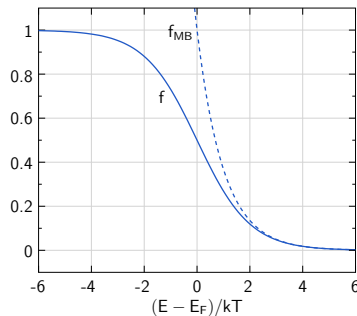
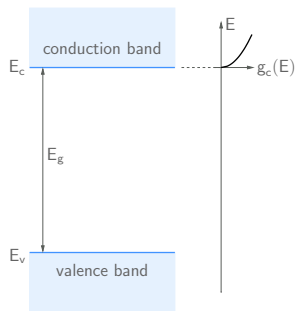


Electron density (n) in equilibrium



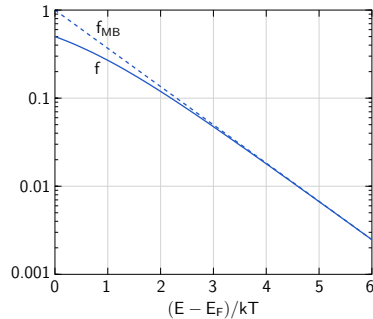
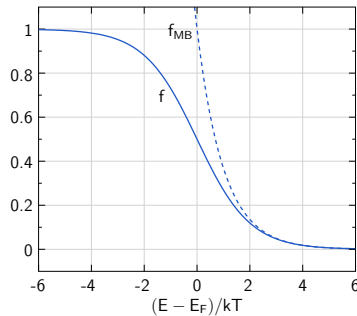
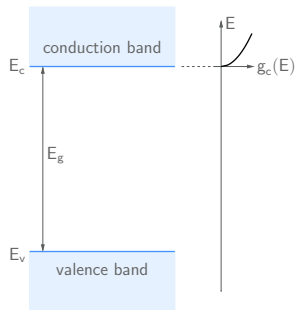
* $f(E)$ is given by the Fermi function: $f(E) = \frac{1}{1 + e^{(E - E_F)/kT}}$ where $k = 1.38 \times 10^{-23}$ J/K (or 8.62×10^{-5} eV/K) is the Boltzmann constant.

Electron density (n) in equilibrium



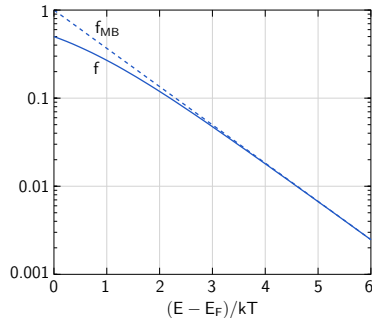
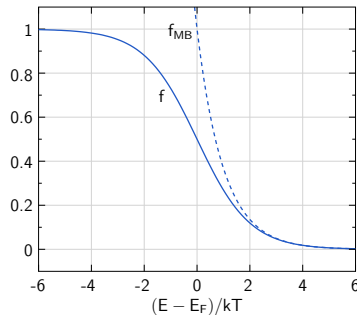
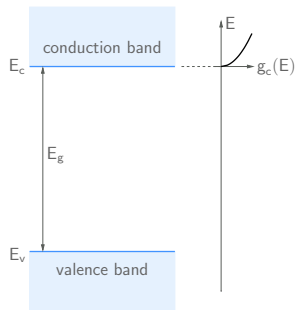
- * $f(E)$ is given by the Fermi function: $f(E) = \frac{1}{1 + e^{(E - E_F)/kT}}$ where $k = 1.38 \times 10^{-23} \text{ J/K}$ (or $8.62 \times 10^{-5} \text{ eV/K}$) is the Boltzmann constant.
- * At $E = E_F$, $f(E) = 1/2$.

Electron density (n) in equilibrium



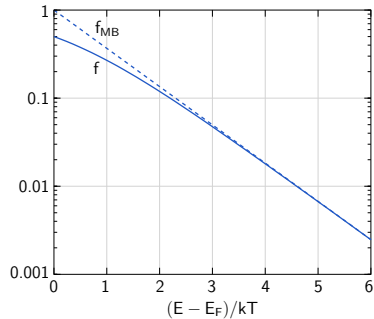
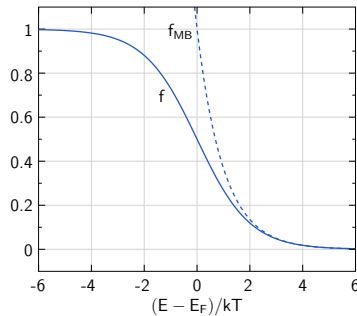
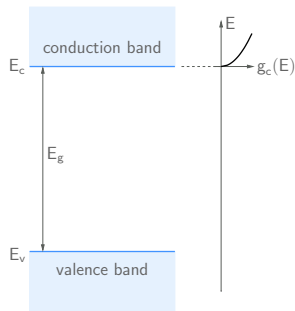
- * $f(E)$ is given by the Fermi function: $f(E) = \frac{1}{1 + e^{(E-E_F)/kT}}$ where $k = 1.38 \times 10^{-23}$ J/K (or 8.62×10^{-5} eV/K) is the Boltzmann constant.
- * At $E = E_F$, $f(E) = 1/2$.
- * If $E - E_F \gg kT$, $e^{(E-E_F)/kT} \gg 1$, and $f(E) \rightarrow 0$.

Electron density (n) in equilibrium



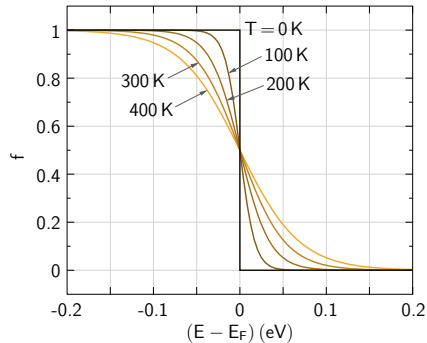
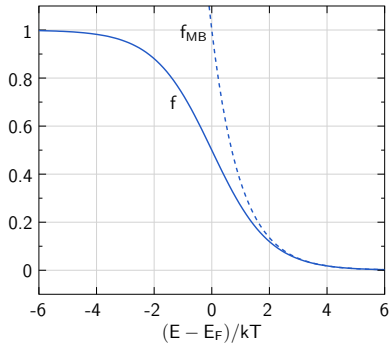
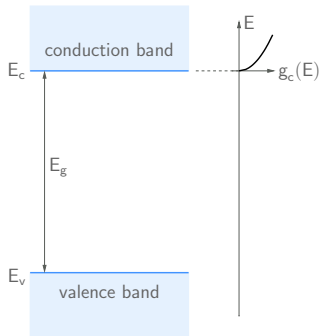
- * $f(E)$ is given by the Fermi function: $f(E) = \frac{1}{1 + e^{(E-E_F)/kT}}$ where $k = 1.38 \times 10^{-23}$ J/K (or 8.62×10^{-5} eV/K) is the Boltzmann constant.
- * At $E = E_F$, $f(E) = 1/2$.
- * If $E - E_F \gg kT$, $e^{(E-E_F)/kT} \gg 1$, and $f(E) \rightarrow 0$.
If $E - E_F \ll -kT$, $e^{(E-E_F)/kT} \ll 1$, and $f(E) \rightarrow 1$.

Electron density (n) in equilibrium

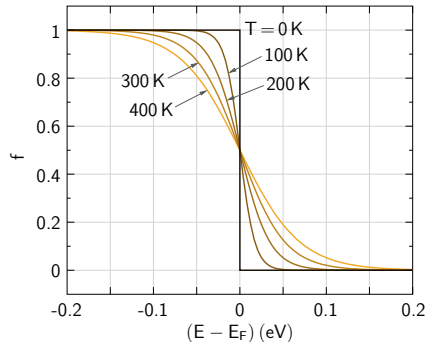
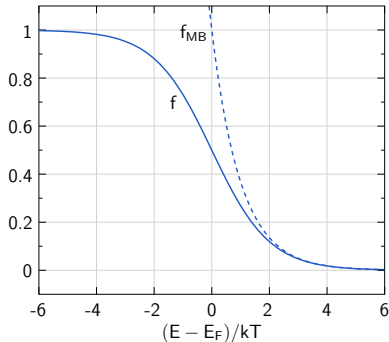
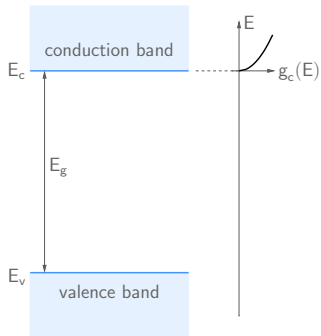


- * $f(E)$ is given by the Fermi function: $f(E) = \frac{1}{1 + e^{(E-E_F)/kT}}$ where $k = 1.38 \times 10^{-23}$ J/K (or 8.62×10^{-5} eV/K) is the Boltzmann constant.
- * At $E = E_F$, $f(E) = 1/2$.
- * If $E - E_F \gg kT$, $e^{(E-E_F)/kT} \gg 1$, and $f(E) \rightarrow 0$.
If $E - E_F \ll -kT$, $e^{(E-E_F)/kT} \ll 1$, and $f(E) \rightarrow 1$.
- * For $E - E_F > 3kT$, $e^{(E-E_F)/kT} > 20$, which is much larger than 1. We then have $f(E) \approx f_{MB}(E) = e^{-(E-E_F)/kT}$, the Maxwell-Boltzmann function.

Electron density (n) in equilibrium

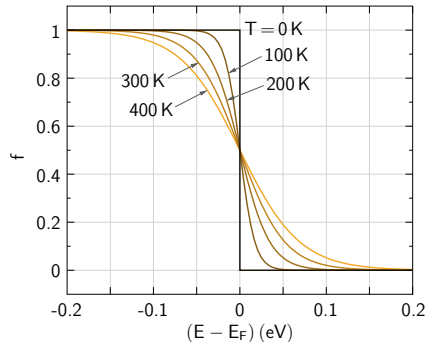
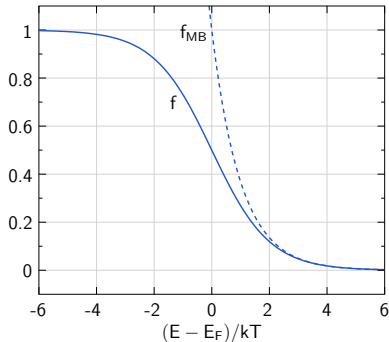
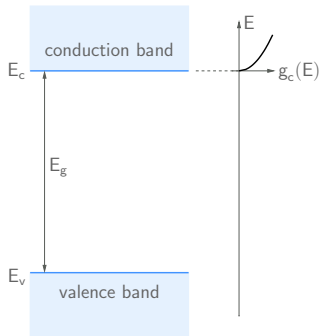


Electron density (n) in equilibrium



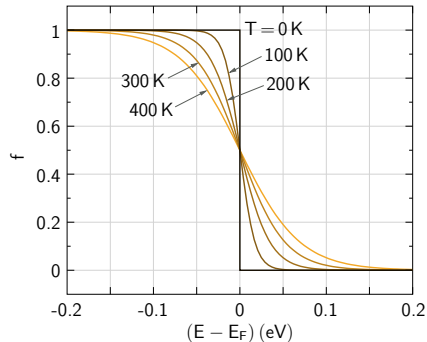
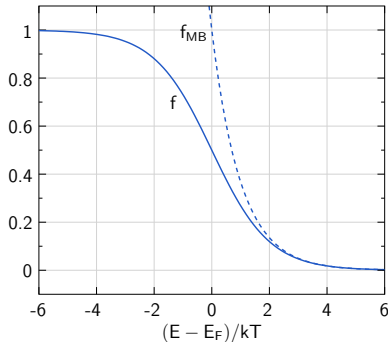
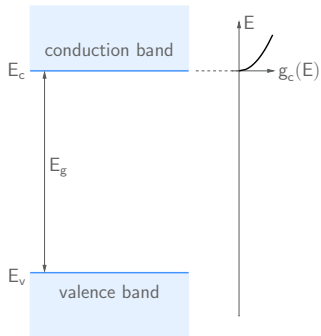
- * Low T : $e^{(E-E_F)/kT}$ varies rapidly with E .
- High T : $e^{(E-E_F)/kT}$ varies slowly with E .

Electron density (n) in equilibrium

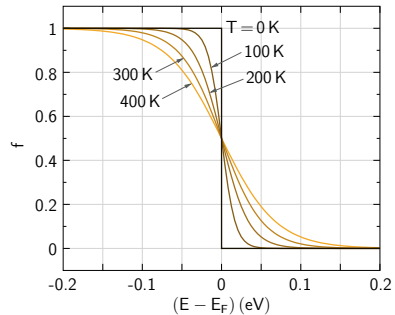
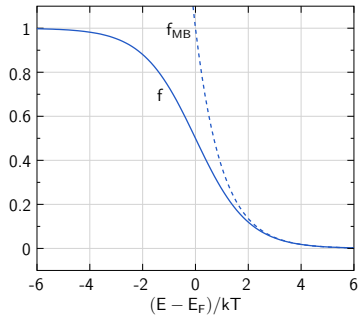
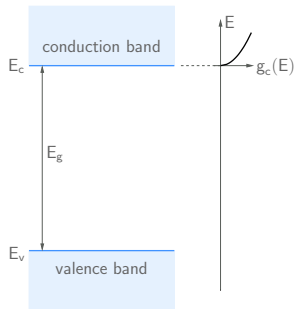


- * Low T : $e^{(E-E_F)/kT}$ varies rapidly with E .
- High T : $e^{(E-E_F)/kT}$ varies slowly with E .
- $\rightarrow f(E)$ becomes broader as T increases.

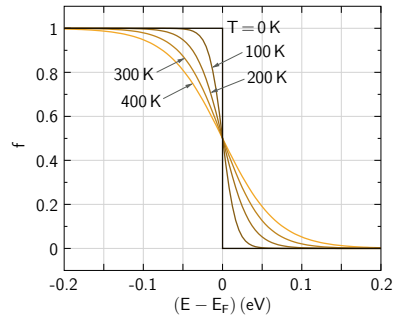
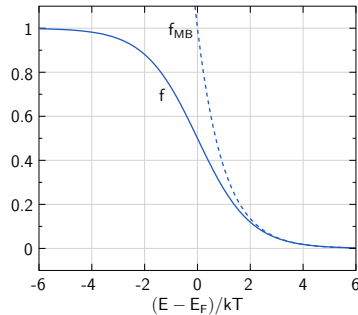
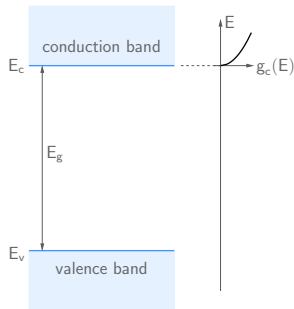
Electron density (n) in equilibrium



- * Low T : $e^{(E-E_F)/kT}$ varies rapidly with E .
High T : $e^{(E-E_F)/kT}$ varies slowly with E .
→ $f(E)$ becomes broader as T increases.
- * Because of the significant variation of $f(E)$ with temperature, we can expect the electron density to have a significant temperature dependence.

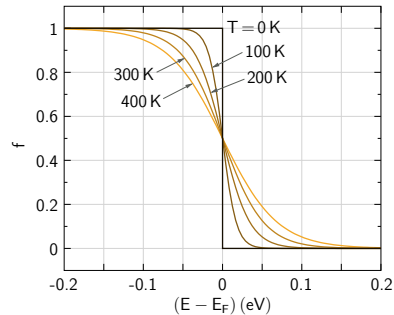
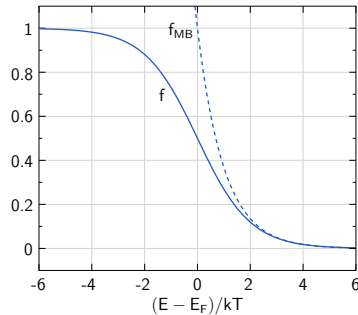
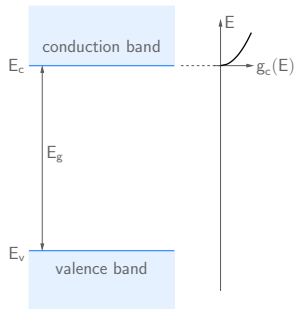


$$n = \int_{E_c}^{\infty} g_c(E) f(E) dE = \frac{(m_n^*)^{3/2} \sqrt{2}}{\pi^2 \hbar^3} \int_{E_c}^{\infty} \frac{\sqrt{E - E_c}}{1 + e^{(E - E_F)/kT}} dE = \frac{(m_n^*)^{3/2}}{\pi^2 \hbar^3} \sqrt{2} (kT)^{3/2} \int_0^{\infty} \frac{\eta^{1/2}}{1 + e^{\eta - \eta_c}} d\eta$$



$$n = \int_{E_c}^{\infty} g_c(E) f(E) dE = \frac{(m_n^*)^{3/2} \sqrt{2}}{\pi^2 \hbar^3} \int_{E_c}^{\infty} \frac{\sqrt{E - E_c}}{1 + e^{(E - E_F)/kT}} dE = \frac{(m_n^*)^{3/2}}{\pi^2 \hbar^3} \sqrt{2} (kT)^{3/2} \int_0^{\infty} \frac{\eta^{1/2}}{1 + e^{\eta - \eta_c}} d\eta$$

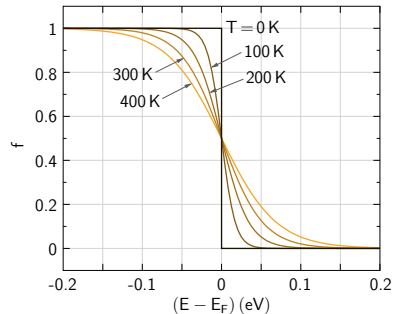
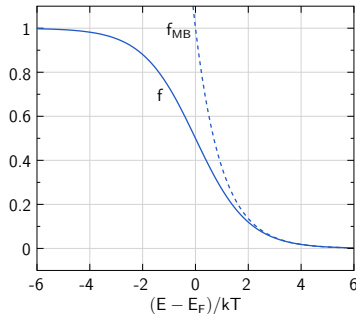
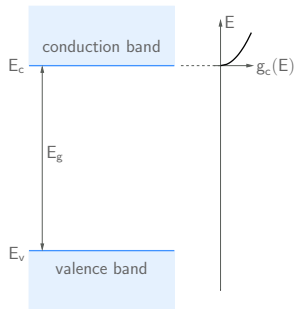
$$\rightarrow n = N_c \frac{2}{\sqrt{\pi}} \mathcal{F}_{1/2}(\eta_c) \text{ with } \eta_c = \frac{E_F - E_c}{kT}.$$



$$n = \int_{E_c}^{\infty} g_c(E) f(E) dE = \frac{(m_n^*)^{3/2} \sqrt{2}}{\pi^2 \hbar^3} \int_{E_c}^{\infty} \frac{\sqrt{E - E_c}}{1 + e^{(E - E_F)/kT}} dE = \frac{(m_n^*)^{3/2}}{\pi^2 \hbar^3} \sqrt{2} (kT)^{3/2} \int_0^{\infty} \frac{\eta^{1/2}}{1 + e^{\eta - \eta_c}} d\eta$$

$$\rightarrow n = N_c \frac{2}{\sqrt{\pi}} \mathcal{F}_{1/2}(\eta_c) \text{ with } \eta_c = \frac{E_F - E_c}{kT}.$$

$$* \mathcal{F}_{1/2}(\eta_c) = \int_0^{\infty} \frac{\eta^{1/2}}{1 + e^{\eta - \eta_c}} d\eta, \text{ is called the "Fermi-Dirac integral of order } 1/2."$$

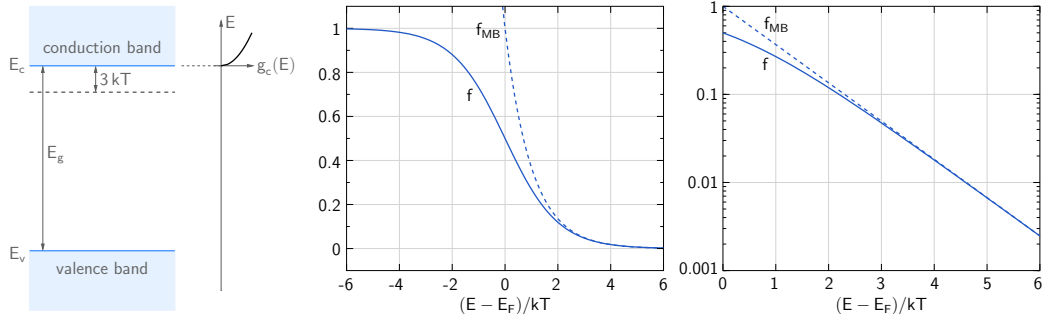


$$n = \int_{E_c}^{\infty} g_c(E) f(E) dE = \frac{(m_n^*)^{3/2} \sqrt{2}}{\pi^2 \hbar^3} \int_{E_c}^{\infty} \frac{\sqrt{E - E_c}}{1 + e^{(E - E_F)/kT}} dE = \frac{(m_n^*)^{3/2}}{\pi^2 \hbar^3} \sqrt{2} (kT)^{3/2} \int_0^{\infty} \frac{\eta^{1/2}}{1 + e^{\eta - \eta_c}} d\eta$$

$$\rightarrow n = N_c \frac{2}{\sqrt{\pi}} \mathcal{F}_{1/2}(\eta_c) \text{ with } \eta_c = \frac{E_F - E_c}{kT}.$$

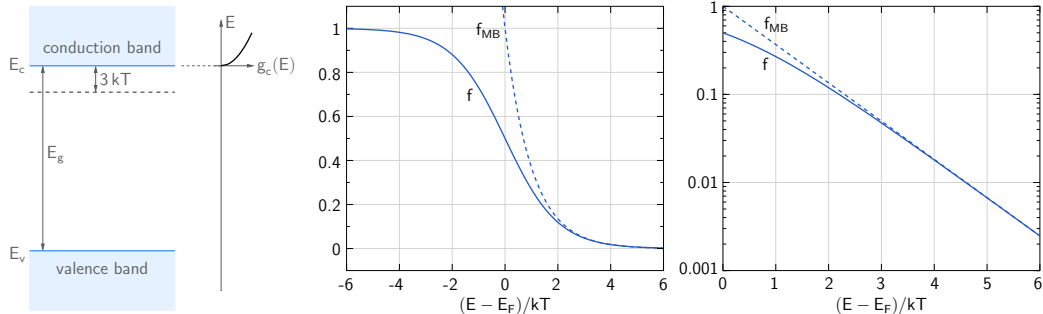
* $\mathcal{F}_{1/2}(\eta_c) = \int_0^{\infty} \frac{\eta^{1/2}}{1 + e^{\eta - \eta_c}} d\eta$, is called the “Fermi-Dirac integral of order 1/2.”

* $N_c = 2 \left[\frac{m_n^* kT}{2\pi \hbar^2} \right]^{3/2}$ is called the “effective” density of states for the conduction band.



When the Fermi level is below $E_c - 3kT$, $f(E) \approx f_{MB}(E)$, and

$$\begin{aligned}
 n &= \frac{(m_n^*)^{3/2} \sqrt{2}}{\pi^2 \hbar^3} \int_{E_c}^{\infty} \sqrt{E - E_c} \left(e^{-(E - E_F)/kT} \right) dE \\
 &= \frac{(m_n^*)^{3/2} \sqrt{2}}{\pi^2 \hbar^3} (kT)^{3/2} \int_0^{\infty} \sqrt{\eta} e^{-\eta} \left(e^{-(E_c - E_F)/kT} \right) d\eta.
 \end{aligned}$$

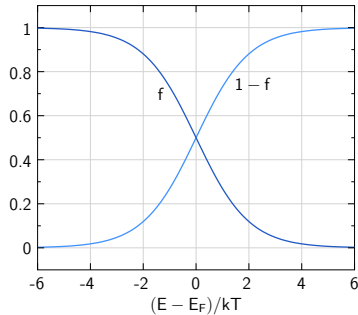
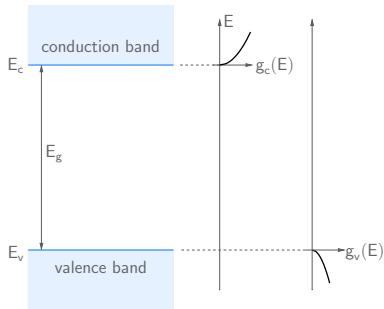


When the Fermi level is below $E_c - 3kT$, $f(E) \approx f_{MB}(E)$, and

$$\begin{aligned}
 n &= \frac{(m_n^*)^{3/2} \sqrt{2}}{\pi^2 \hbar^3} \int_{E_c}^{\infty} \sqrt{E - E_c} \left(e^{-(E - E_F)/kT} \right) dE \\
 &= \frac{(m_n^*)^{3/2} \sqrt{2}}{\pi^2 \hbar^3} (kT)^{3/2} \int_0^{\infty} \sqrt{\eta} e^{-\eta} \left(e^{-(E_c - E_F)/kT} \right) d\eta.
 \end{aligned}$$

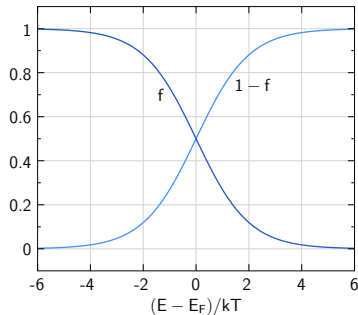
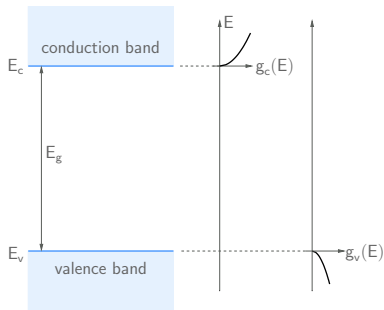
$$\int_0^{\infty} \sqrt{\eta} e^{-\eta} d\eta = \frac{\sqrt{\pi}}{2} \rightarrow n = \frac{(m_n^*)^{3/2} \sqrt{2}}{\pi^2 \hbar^3} (kT)^{3/2} \frac{\sqrt{\pi}}{2} e^{-(E_c - E_F)/kT} = N_c e^{-(E_c - E_F)/kT}.$$

Hole density (p) in equilibrium



$$g_v(E) = \frac{(m_p^*)^{3/2} \sqrt{2(E_v - E)}}{\pi^2 \hbar^3}, \quad E < E_v, \quad p = \int_{-\infty}^{E_v} g_v(E) (1 - f(E)) dE.$$

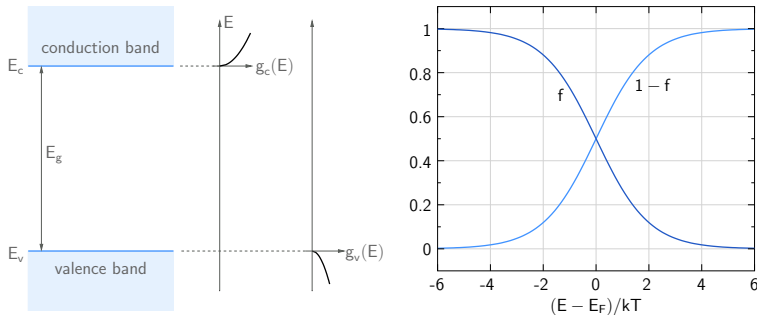
Hole density (p) in equilibrium



$$g_v(E) = \frac{(m_p^*)^{3/2} \sqrt{2(E_v - E)}}{\pi^2 \hbar^3}, \quad E < E_v, \quad p = \int_{-\infty}^{E_v} g_v(E) (1 - f(E)) dE.$$

$$p = \frac{(m_p^*)^{3/2}}{\pi^2 \hbar^3} \int_{-\infty}^{E_v} \frac{\sqrt{2(E_v - E)}}{1 + e^{-(E - E_F)/kT}} dE$$

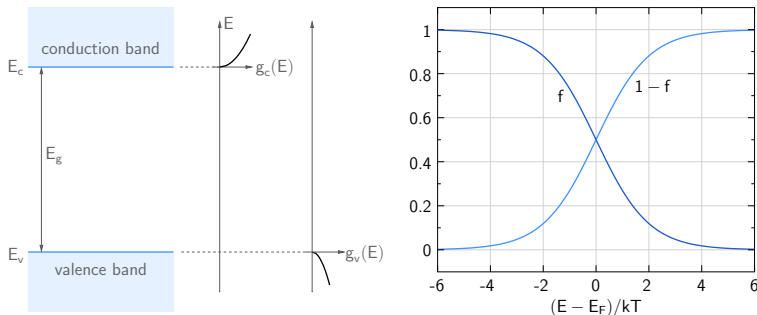
Hole density (p) in equilibrium



$$g_v(E) = \frac{(m_p^*)^{3/2} \sqrt{2(E_v - E)}}{\pi^2 \hbar^3}, \quad E < E_v, \quad p = \int_{-\infty}^{E_v} g_v(E) (1 - f(E)) dE.$$

$$\begin{aligned} p &= \frac{(m_p^*)^{3/2}}{\pi^2 \hbar^3} \int_{-\infty}^{E_v} \frac{\sqrt{2(E_v - E)}}{1 + e^{-(E - E_F)/kT}} dE \\ &= \frac{(m_p^*)^{3/2}}{\pi^2 \hbar^3} \sqrt{2} (kT)^{3/2} \int_0^{\infty} \frac{\eta^{1/2}}{1 + e^{\eta - \eta_v}} d\eta, \quad \text{with } \eta = \frac{E_v - E}{kT} \text{ and } \eta_v = \frac{E_v - E_F}{kT} \end{aligned}$$

Hole density (p) in equilibrium



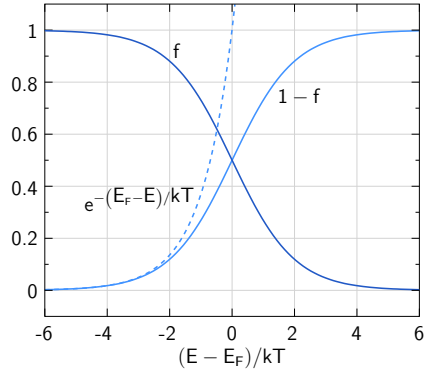
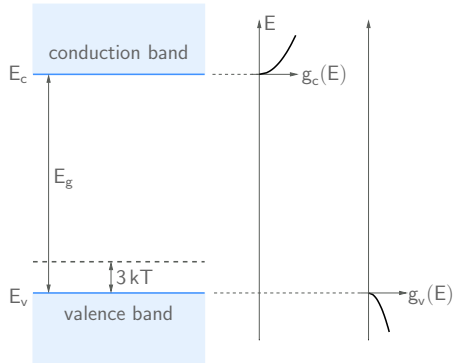
$$g_v(E) = \frac{(m_p^*)^{3/2} \sqrt{2(E_v - E)}}{\pi^2 \hbar^3}, \quad E < E_v, \quad p = \int_{-\infty}^{E_v} g_v(E) (1 - f(E)) dE.$$

$$p = \frac{(m_p^*)^{3/2}}{\pi^2 \hbar^3} \int_{-\infty}^{E_v} \frac{\sqrt{2(E_v - E)}}{1 + e^{-(E - E_F)/kT}} dE$$

$$= \frac{(m_p^*)^{3/2}}{\pi^2 \hbar^3} \sqrt{2} (kT)^{3/2} \int_0^{\infty} \frac{\eta^{1/2}}{1 + e^{\eta - \eta_v}} d\eta, \quad \text{with } \eta = \frac{E_v - E}{kT} \text{ and } \eta_v = \frac{E_v - E_F}{kT}$$

$$= N_v \frac{2}{\sqrt{\pi}} \mathcal{F}_{1/2}(\eta_v), \quad \text{where } N_v = 2 \left[\frac{m_p^* kT}{2\pi \hbar^2} \right]^{3/2} \text{ is the effective density of states for the valence band.}$$

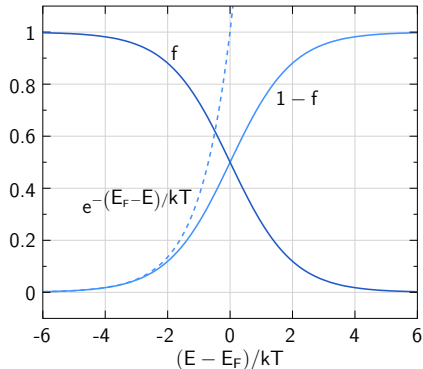
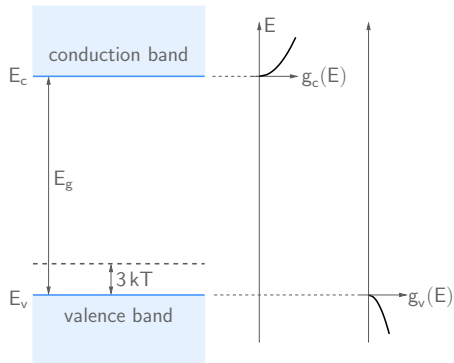
Hole density (p) in equilibrium



When $E_F > E_v + 3kT$, $1 - f(E)$ can be approximated using the Maxwell-Boltzmann function.

$$1 - f(E) \approx e^{-(E_F - E)/kT} \rightarrow p = N_v e^{-(E_F - E_v)/kT}.$$

Hole density (p) in equilibrium



When $E_F > E_v + 3kT$, $1 - f(E)$ can be approximated using the Maxwell-Boltzmann function.

$$1 - f(E) \approx e^{-(E_F - E)/kT} \rightarrow p = N_v e^{-(E_F - E_v)/kT}.$$





$$E_F > E_c - 3kT$$

(degenerate semiconductor)

$$n = N_c \frac{2}{\sqrt{\pi}} \mathcal{F}_{1/2}(\eta_c), \quad \eta_c = - \left(\frac{E_c - E_F}{kT} \right)$$

$$p = N_v e^{-(E_F - E_v)/kT}$$



$$E_F < E_v + 3kT$$

(degenerate semiconductor)

$$n = N_c e^{-(E_c - E_F)/kT}$$

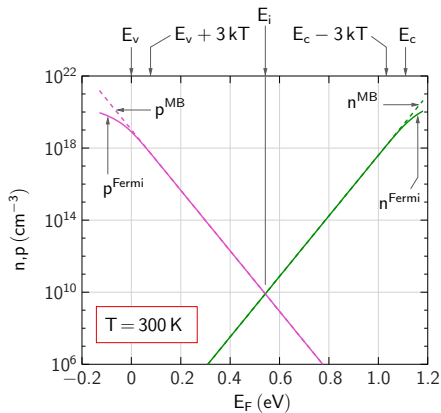
$$p = N_v \frac{2}{\sqrt{\pi}} \mathcal{F}_{1/2}(\eta_v), \quad \eta_v = - \left(\frac{E_F - E_v}{kT} \right)$$

$$E_v + 3kT < E_F < E_c - 3kT$$

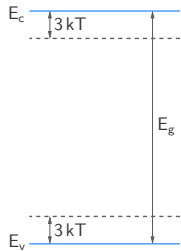
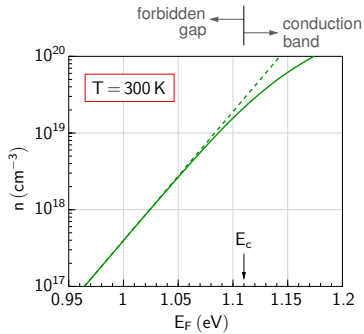
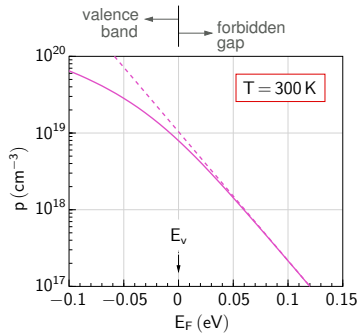
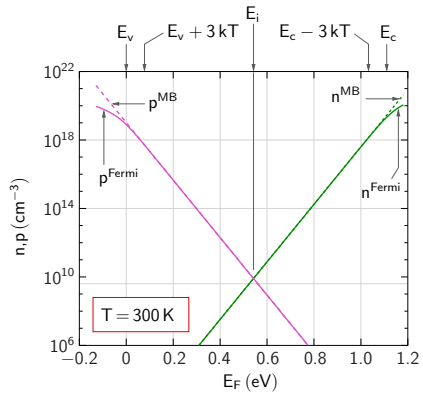
(non-degenerate semiconductor)

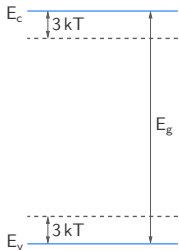
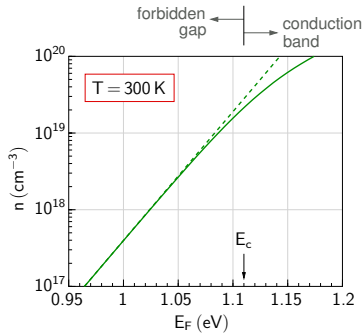
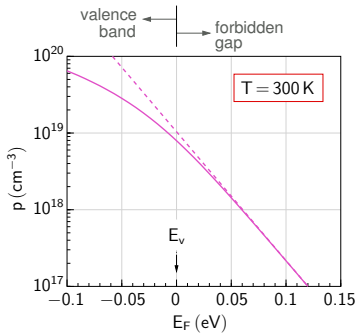
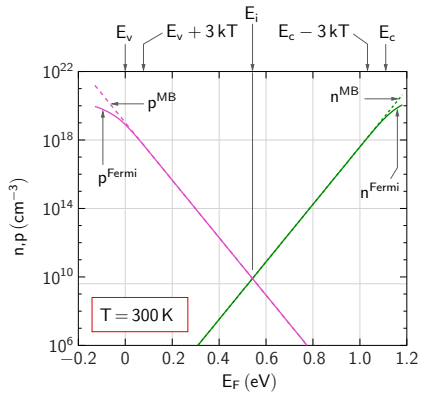
$$n = N_c e^{-(E_c - E_F)/kT}$$

$$p = N_v e^{-(E_F - E_v)/kT}$$



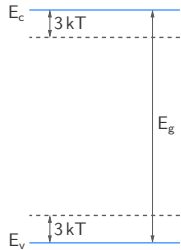
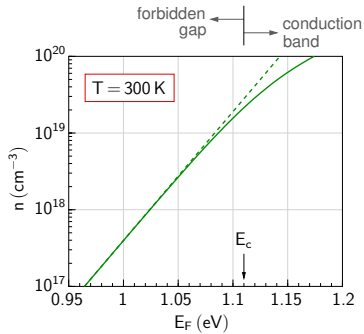
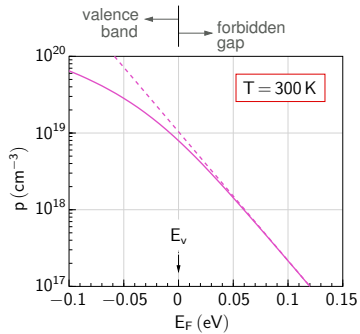
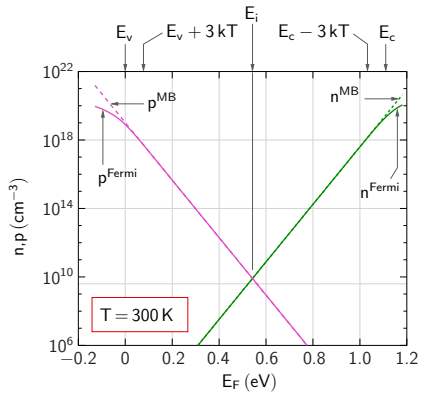
Electron and hole densities in silicon





$$* n^{\text{Fermi}} = N_c \frac{2}{\sqrt{\pi}} \mathcal{F}_{1/2}(\eta_c), \quad \eta_c = -\left(\frac{E_c - E_F}{kT}\right)$$

$$* n^{\text{MB}} = N_c e^{-(E_c - E_F)/kT}$$

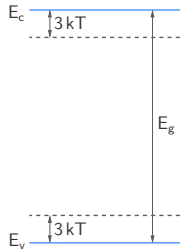
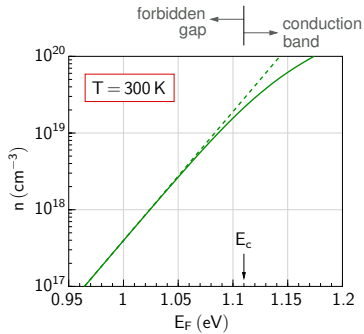
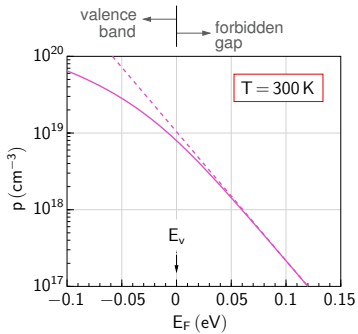
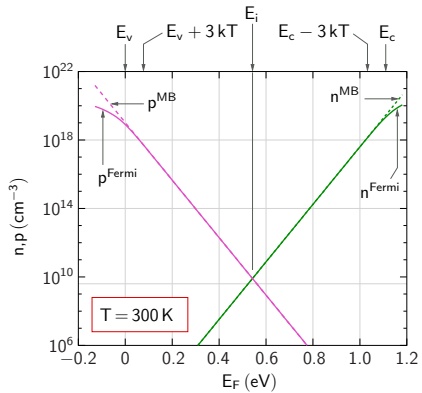


$$* n^{\text{Fermi}} = N_c \frac{2}{\sqrt{\pi}} \mathcal{F}_{1/2}(\eta_c), \quad \eta_c = -\left(\frac{E_c - E_F}{kT}\right)$$

$$* p^{\text{Fermi}} = N_v \frac{2}{\sqrt{\pi}} \mathcal{F}_{1/2}(\eta_v), \quad \eta_v = -\left(\frac{E_F - E_v}{kT}\right)$$

$$* n^{\text{MB}} = N_c e^{-(E_c - E_F)/kT}$$

$$* p^{\text{MB}} = N_v e^{-(E_F - E_v)/kT}$$



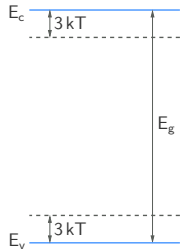
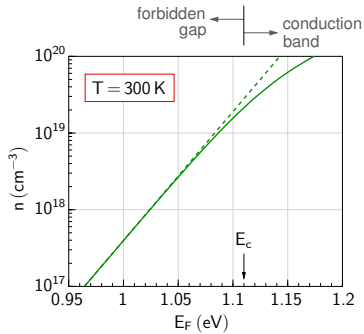
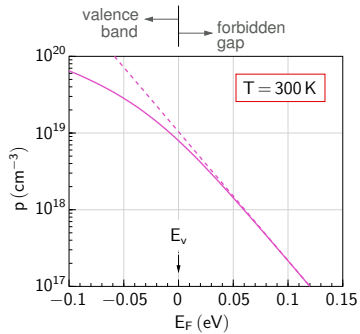
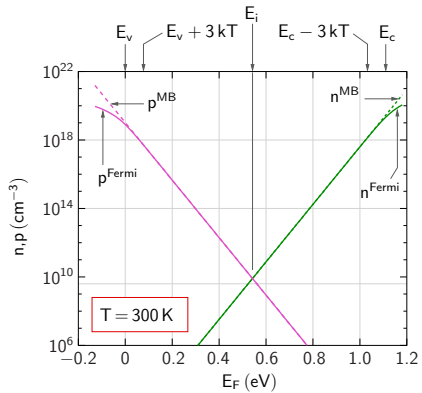
$$* n^{\text{Fermi}} = N_c \frac{2}{\sqrt{\pi}} \mathcal{F}_{1/2}(\eta_c), \quad \eta_c = -\left(\frac{E_c - E_F}{kT}\right)$$

$$* p^{\text{Fermi}} = N_v \frac{2}{\sqrt{\pi}} \mathcal{F}_{1/2}(\eta_v), \quad \eta_v = -\left(\frac{E_F - E_v}{kT}\right)$$

$$* \text{For } E_F < (E_c - 3kT), \quad n^{\text{MB}} \approx n^{\text{Fermi}}$$

$$* n^{\text{MB}} = N_c e^{-(E_c - E_F)/kT}$$

$$* p^{\text{MB}} = N_v e^{-(E_F - E_v)/kT}$$



- * $n^{\text{Fermi}} = N_c \frac{2}{\sqrt{\pi}} \mathcal{F}_{1/2}(\eta_c), \quad \eta_c = -\left(\frac{E_c - E_F}{kT}\right)$
- * $p^{\text{Fermi}} = N_v \frac{2}{\sqrt{\pi}} \mathcal{F}_{1/2}(\eta_v), \quad \eta_v = -\left(\frac{E_F - E_v}{kT}\right)$
- * For $E_F < (E_c - 3kT)$, $n^{\text{MB}} \approx n^{\text{Fermi}}$
- * For $E_F > (E_v + 3kT)$, $p^{\text{MB}} \approx p^{\text{Fermi}}$

- * $n^{\text{MB}} = N_c e^{-(E_c - E_F)/kT}$
- * $p^{\text{MB}} = N_v e^{-(E_F - E_v)/kT}$

For silicon at $T = 300\text{ K}$ and in equilibrium (with $N_c = 2.8 \times 10^{19}\text{ cm}^{-3}$, $N_v = 1.04 \times 10^{19}\text{ cm}^{-3}$, $E_g = 1.12\text{ eV}$),

For silicon at $T = 300\text{ K}$ and in equilibrium (with $N_c = 2.8 \times 10^{19}\text{ cm}^{-3}$, $N_v = 1.04 \times 10^{19}\text{ cm}^{-3}$, $E_g = 1.12\text{ eV}$),

- (a) Find E_F for which n and p are equal. This Fermi level is called E_i , the “intrinsic” Fermi level.

For silicon at $T = 300\text{ K}$ and in equilibrium (with $N_c = 2.8 \times 10^{19}\text{ cm}^{-3}$, $N_v = 1.04 \times 10^{19}\text{ cm}^{-3}$, $E_g = 1.12\text{ eV}$),

- (a) Find E_F for which n and p are equal. This Fermi level is called E_i , the “intrinsic” Fermi level.
- (b) Obtain expressions for n and p in terms of $(E_i - E_F)$ (instead of $(E_c - E_F)$ and $(E_F - E_v)$). Assume non-degenerate conditions.

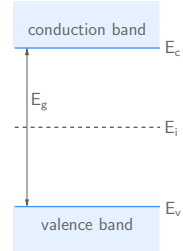
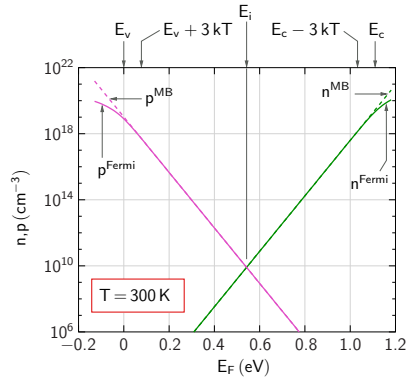
For silicon at $T = 300\text{ K}$ and in equilibrium (with $N_c = 2.8 \times 10^{19}\text{ cm}^{-3}$, $N_v = 1.04 \times 10^{19}\text{ cm}^{-3}$, $E_g = 1.12\text{ eV}$),

- (a) Find E_F for which n and p are equal. This Fermi level is called E_i , the “intrinsic” Fermi level.
- (b) Obtain expressions for n and p in terms of $(E_i - E_F)$ (instead of $(E_c - E_F)$ and $(E_F - E_v)$). Assume non-degenerate conditions.
- (c) Plot $g_c(E) f(E)$ and $g_v(E) [1 - f(E)]$ versus E for
 - $E_F = E_i + 20\text{ meV}$,
 - $E_F = E_i + 10\text{ meV}$,
 - $E_F = E_i$,
 - $E_F = E_i - 10\text{ meV}$,
 - $E_F = E_i - 20\text{ meV}$.

The condition $n = p$ is satisfied when E_F is about $(E_v + E_c)/2$.

→ We can use MB statistics, i.e.,

$$N_c e^{-(E_c - E_F)/kT} = N_v e^{-(E_F - E_v)/kT}$$

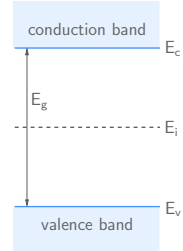
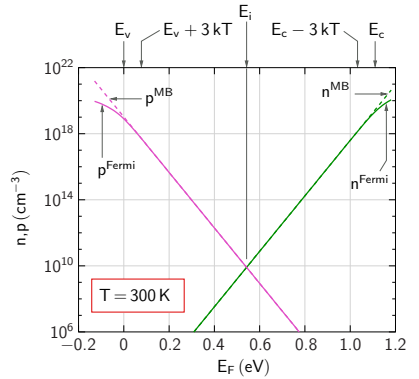


The condition $n = p$ is satisfied when E_F is about $(E_v + E_c)/2$.

→ We can use MB statistics, i.e.,

$$N_c e^{-(E_c - E_F)/kT} = N_v e^{-(E_F - E_v)/kT}$$

$$\rightarrow -E_c + E_F + E_F - E_v = kT \log \frac{N_v}{N_c}.$$



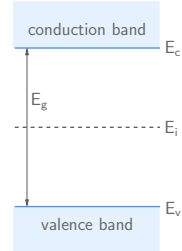
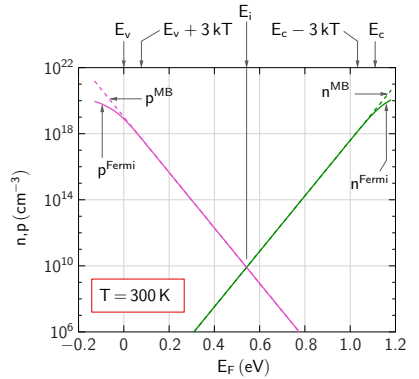
The condition $n = p$ is satisfied when E_F is about $(E_v + E_c)/2$.

→ We can use MB statistics, i.e.,

$$N_c e^{-(E_c - E_F)/kT} = N_v e^{-(E_F - E_v)/kT}$$

$$\rightarrow -E_c + E_F + E_F - E_v = kT \log \frac{N_v}{N_c}.$$

$$\rightarrow E_F = \frac{1}{2} (E_c + E_v) + \frac{kT}{2} \log \frac{N_v}{N_c}.$$



The condition $n = p$ is satisfied when E_F is about $(E_v + E_c)/2$.

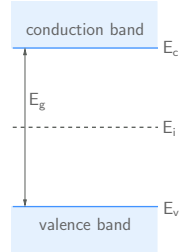
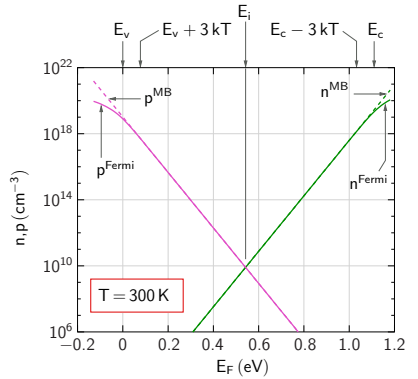
→ We can use MB statistics, i.e.,

$$N_c e^{-(E_c - E_F)/kT} = N_v e^{-(E_F - E_v)/kT}$$

$$\rightarrow -E_c + E_F + E_F - E_v = kT \log \frac{N_v}{N_c}.$$

$$\rightarrow E_F = \frac{1}{2} (E_c + E_v) + \frac{kT}{2} \log \frac{N_v}{N_c}.$$

$$N_v/N_c = (m_p^*/m_n^*)^{3/2} \rightarrow E_F \equiv E_i = \frac{1}{2} (E_c + E_v) + \frac{3}{4} kT \log \frac{m_p^*}{m_n^*}.$$



The condition $n = p$ is satisfied when E_F is about $(E_v + E_c)/2$.

→ We can use MB statistics, i.e.,

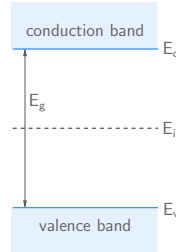
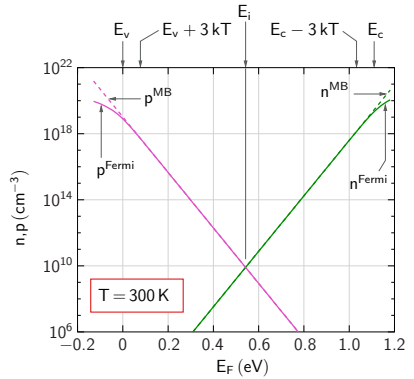
$$N_c e^{-(E_c - E_F)/kT} = N_v e^{-(E_F - E_v)/kT}$$

$$\rightarrow -E_c + E_F + E_F - E_v = kT \log \frac{N_v}{N_c}.$$

$$\rightarrow E_F = \frac{1}{2} (E_c + E_v) + \frac{kT}{2} \log \frac{N_v}{N_c}.$$

$$N_v/N_c = (m_p^*/m_n^*)^{3/2} \rightarrow E_F \equiv E_i = \frac{1}{2} (E_c + E_v) + \frac{3}{4} kT \log \frac{m_p^*}{m_n^*}.$$

- * The second term in the above equation is about -7.3 meV, i.e., the intrinsic Fermi level E_i is located 7.3 meV below the centre of the band gap.



The condition $n = p$ is satisfied when E_F is about $(E_v + E_c)/2$.

→ We can use MB statistics, i.e.,

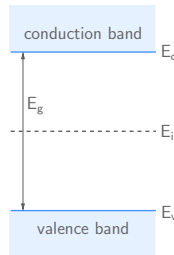
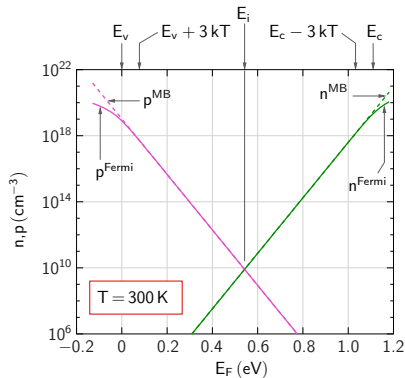
$$N_c e^{-(E_c - E_F)/kT} = N_v e^{-(E_F - E_v)/kT}$$

$$\rightarrow -E_c + E_F + E_F - E_v = kT \log \frac{N_v}{N_c}.$$

$$\rightarrow E_F = \frac{1}{2} (E_c + E_v) + \frac{kT}{2} \log \frac{N_v}{N_c}.$$

$$N_v/N_c = (m_p^*/m_n^*)^{3/2} \rightarrow E_F \equiv E_i = \frac{1}{2} (E_c + E_v) + \frac{3}{4} kT \log \frac{m_p^*}{m_n^*}.$$

- * The second term in the above equation is about -7.3 meV, i.e., the intrinsic Fermi level E_i is located 7.3 meV below the centre of the band gap.
- * If N_c and N_v were equal, E_i would be exactly at the centre of the band gap.



When $E_F = E_i$, we have $n = p \equiv n_i$, the “intrinsic carrier concentration.”

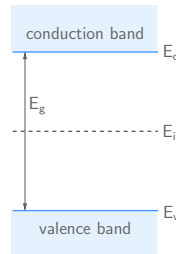
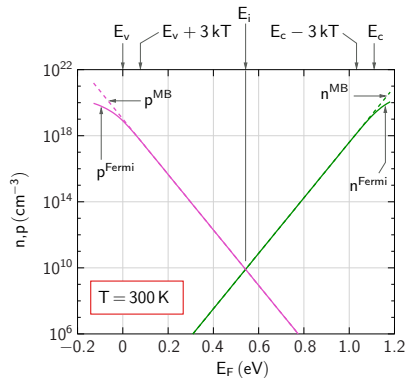
The actual electron concentration (for a given Fermi level E_F) can be written in terms of n_i as follows.

$$n = N_c e^{-(E_c - E_F)/kT}, \quad n_i = N_c e^{-(E_c - E_i)/kT}.$$

$$\rightarrow \frac{n}{n_i} = e^{(E_F - E_i)/kT} \rightarrow n = n_i e^{(E_F - E_i)/kT}.$$

Similarly, for the hole concentration p , we obtain

$$p = n_i e^{(E_i - E_F)/kT}.$$



When $E_F = E_i$, we have $n = p \equiv n_i$, the “intrinsic carrier concentration.”

The actual electron concentration (for a given Fermi level E_F) can be written in terms of n_i as follows.

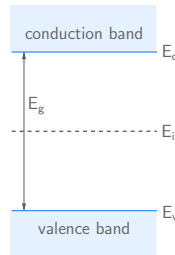
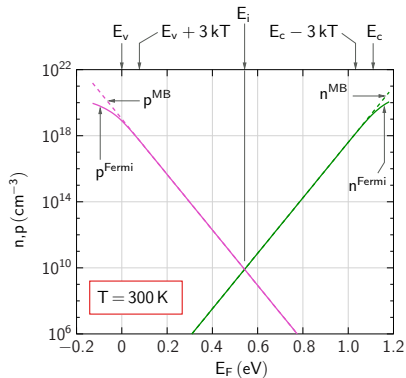
$$n = N_c e^{-(E_c - E_F)/kT}, \quad n_i = N_c e^{-(E_c - E_i)/kT}.$$

$$\rightarrow \frac{n}{n_i} = e^{(E_F - E_i)/kT} \rightarrow n = n_i e^{(E_F - E_i)/kT}.$$

Similarly, for the hole concentration p , we obtain

$$p = n_i e^{(E_i - E_F)/kT}.$$

* for $E_F > E_i$, $n > p$.



When $E_F = E_i$, we have $n = p \equiv n_i$, the “intrinsic carrier concentration.”

The actual electron concentration (for a given Fermi level E_F) can be written in terms of n_i as follows.

$$n = N_c e^{-(E_c - E_F)/kT}, \quad n_i = N_c e^{-(E_c - E_i)/kT}.$$

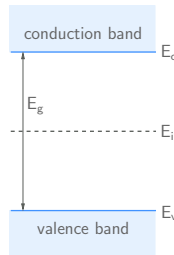
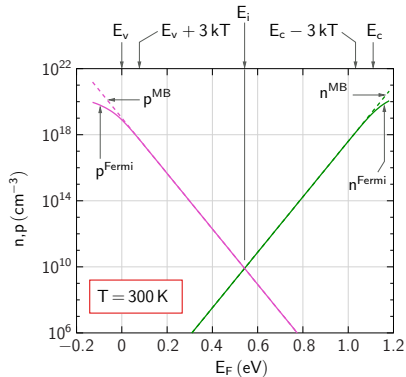
$$\rightarrow \frac{n}{n_i} = e^{(E_F - E_i)/kT} \rightarrow n = n_i e^{(E_F - E_i)/kT}.$$

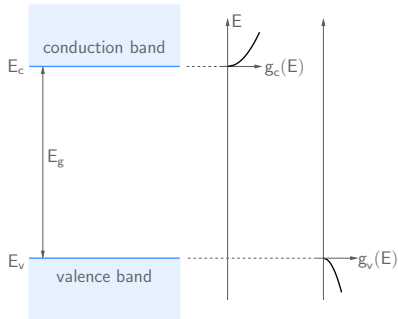
Similarly, for the hole concentration p , we obtain

$$p = n_i e^{(E_i - E_F)/kT}.$$

* for $E_F > E_i$, $n > p$.

* For $E_F < E_i$, $n < p$.





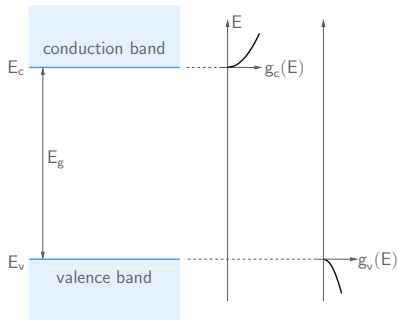
$$* g_c(E) = \frac{(m_n^*)^{3/2} \sqrt{2(E - E_c)}}{\pi^2 \hbar^3}$$

$$* g_v(E) = \frac{(m_p^*)^{3/2} \sqrt{2(E_v - E)}}{\pi^2 \hbar^3}$$

$$* f(E) = \frac{1}{1 + e^{(E - E_F)/kT}}$$

$$* n = \int_{E_c}^{\infty} g_c(E) f(E) dE$$

$$* p = \int_{-\infty}^{E_v} g_v(E) (1 - f(E)) dE$$



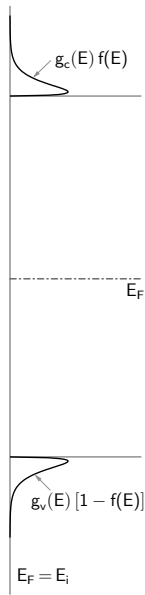
$$* g_c(E) = \frac{(m_n^*)^{3/2} \sqrt{2(E - E_c)}}{\pi^2 \hbar^3}$$

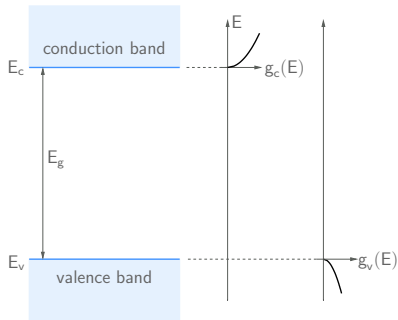
$$* g_v(E) = \frac{(m_p^*)^{3/2} \sqrt{2(E_v - E)}}{\pi^2 \hbar^3}$$

$$* f(E) = \frac{1}{1 + e^{(E - E_F)/kT}}$$

$$* n = \int_{E_c}^{\infty} g_c(E) f(E) dE$$

$$* p = \int_{-\infty}^{E_v} g_v(E) (1 - f(E)) dE$$





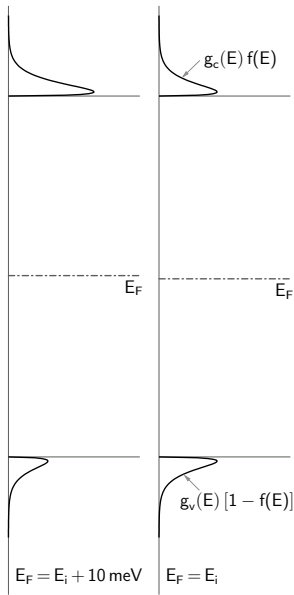
$$* g_c(E) = \frac{(m_n^*)^{3/2} \sqrt{2(E - E_c)}}{\pi^2 \hbar^3}$$

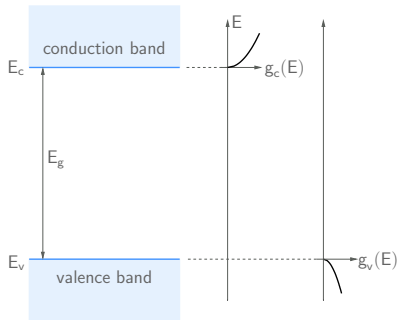
$$* g_v(E) = \frac{(m_p^*)^{3/2} \sqrt{2(E_v - E)}}{\pi^2 \hbar^3}$$

$$* f(E) = \frac{1}{1 + e^{(E - E_F)/kT}}$$

$$* n = \int_{E_c}^{\infty} g_c(E) f(E) dE$$

$$* p = \int_{-\infty}^{E_v} g_v(E) (1 - f(E)) dE$$





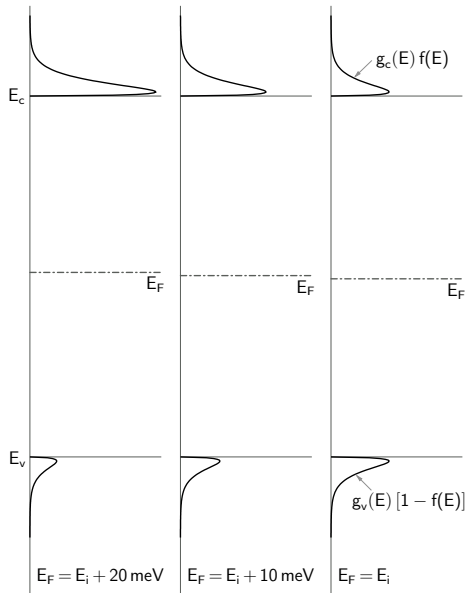
$$* g_c(E) = \frac{(m_n^*)^{3/2} \sqrt{2(E - E_c)}}{\pi^2 \hbar^3}$$

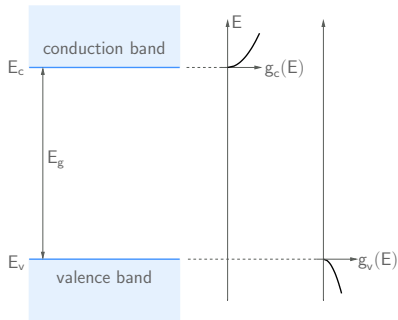
$$* g_v(E) = \frac{(m_p^*)^{3/2} \sqrt{2(E_v - E)}}{\pi^2 \hbar^3}$$

$$* f(E) = \frac{1}{1 + e^{(E - E_F)/kT}}$$

$$* n = \int_{E_c}^{\infty} g_c(E) f(E) dE$$

$$* p = \int_{-\infty}^{E_v} g_v(E) (1 - f(E)) dE$$





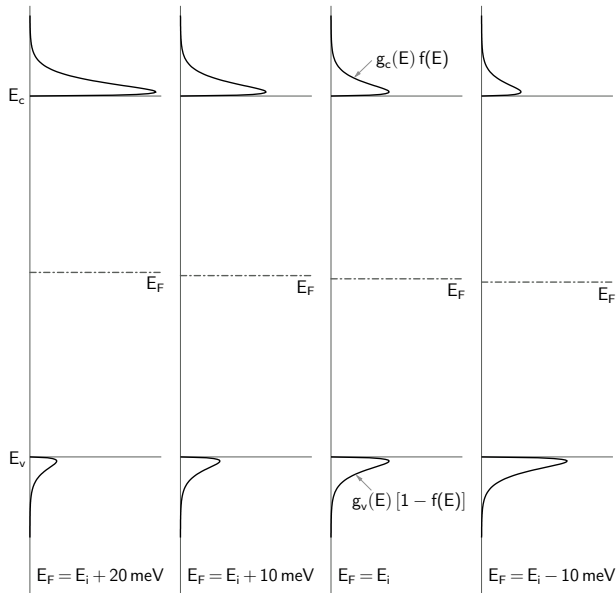
$$* g_c(E) = \frac{(m_n^*)^{3/2} \sqrt{2(E - E_c)}}{\pi^2 \hbar^3}$$

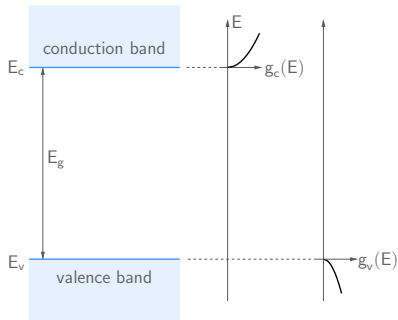
$$* g_v(E) = \frac{(m_p^*)^{3/2} \sqrt{2(E_v - E)}}{\pi^2 \hbar^3}$$

$$* f(E) = \frac{1}{1 + e^{(E - E_F)/kT}}$$

$$* n = \int_{E_c}^{\infty} g_c(E) f(E) dE$$

$$* p = \int_{-\infty}^{E_v} g_v(E) (1 - f(E)) dE$$





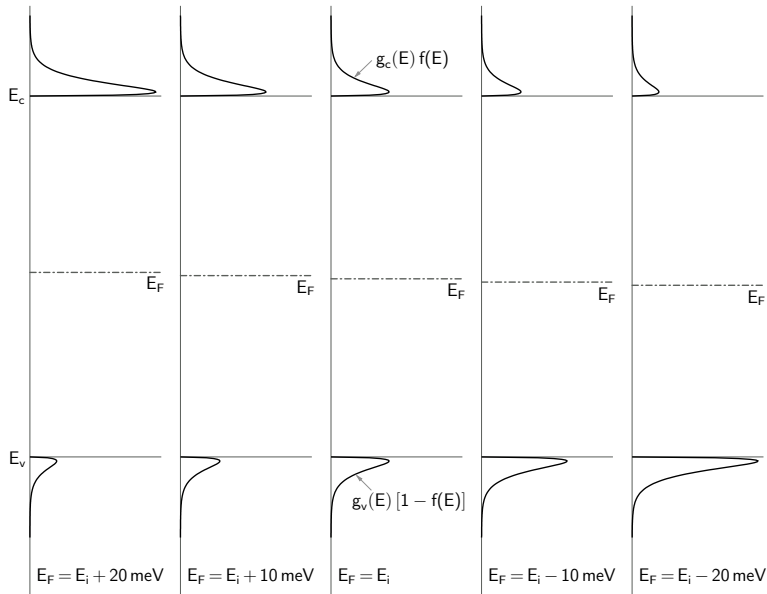
$$* g_c(E) = \frac{(m_n^*)^{3/2} \sqrt{2(E - E_c)}}{\pi^2 \hbar^3}$$

$$* g_v(E) = \frac{(m_p^*)^{3/2} \sqrt{2(E_v - E)}}{\pi^2 \hbar^3}$$

$$* f(E) = \frac{1}{1 + e^{(E - E_F)/kT}}$$

$$* n = \int_{E_c}^{\infty} g_c(E) f(E) dE$$

$$* p = \int_{-\infty}^{E_v} g_v(E) (1 - f(E)) dE$$



$$n = N_c e^{-(E_c - E_F)/kT}, \quad p = N_v e^{-(E_F - E_v)/kT}.$$

When $E_F = E_i$, $n = p = n_i$, i.e.,

$$n = n_i = N_c e^{-(E_c - E_i)/kT}, \quad p = n_i = N_v e^{-(E_i - E_v)/kT}$$

Temperature dependence of n_i

$$n = N_c e^{-(E_c - E_F)/kT}, \quad p = N_v e^{-(E_F - E_v)/kT}.$$

When $E_F = E_i$, $n = p = n_i$, i.e.,

$$n = n_i = N_c e^{-(E_c - E_i)/kT}, \quad p = n_i = N_v e^{-(E_i - E_v)/kT}$$

$$\rightarrow np = n_i^2 = N_c N_v e^{-(E_c - E_v)/kT} = N_c N_v e^{-E_g/kT}$$

Temperature dependence of n_i

$$n = N_c e^{-(E_c - E_F)/kT}, \quad p = N_v e^{-(E_F - E_v)/kT}.$$

When $E_F = E_i$, $n = p = n_i$, i.e.,

$$n = n_i = N_c e^{-(E_c - E_i)/kT}, \quad p = n_i = N_v e^{-(E_i - E_v)/kT}$$

$$\rightarrow np = n_i^2 = N_c N_v e^{-(E_c - E_v)/kT} = N_c N_v e^{-E_g/kT}$$

$$\begin{aligned} \rightarrow n_i &= \sqrt{N_c N_v} e^{-E_g/2kT} \\ &= 2 (m_n^* m_p^*)^{3/4} \left(\frac{kT}{2\pi\hbar^2} \right)^{3/2} e^{-E_g/2kT} \\ &\equiv K T^{3/2} e^{-E_g/2kT} \end{aligned}$$

Temperature dependence of n_i

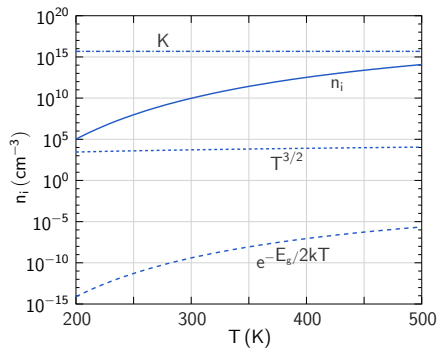
$$n = N_c e^{-(E_c - E_F)/kT}, \quad p = N_v e^{-(E_F - E_v)/kT}.$$

When $E_F = E_i$, $n = p = n_i$, i.e.,

$$n = n_i = N_c e^{-(E_c - E_i)/kT}, \quad p = n_i = N_v e^{-(E_i - E_v)/kT}$$

$$\rightarrow np = n_i^2 = N_c N_v e^{-(E_c - E_v)/kT} = N_c N_v e^{-E_g/kT}$$

$$\begin{aligned} \rightarrow n_i &= \sqrt{N_c N_v} e^{-E_g/2kT} \\ &= 2 (m_n^* m_p^*)^{3/4} \left(\frac{kT}{2\pi\hbar^2} \right)^{3/2} e^{-E_g/2kT} \\ &\equiv K T^{3/2} e^{-E_g/2kT} \end{aligned}$$



Temperature dependence of n_i

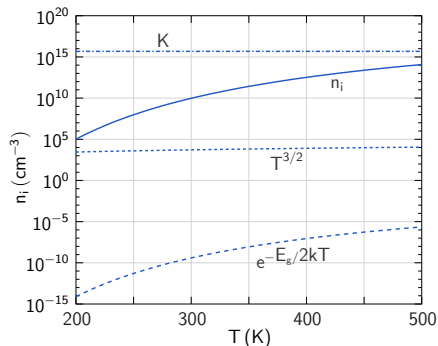
$$n = N_c e^{-(E_c - E_F)/kT}, \quad p = N_v e^{-(E_F - E_v)/kT}.$$

When $E_F = E_i$, $n = p = n_i$, i.e.,

$$n = n_i = N_c e^{-(E_c - E_i)/kT}, \quad p = n_i = N_v e^{-(E_i - E_v)/kT}$$

$$\rightarrow np = n_i^2 = N_c N_v e^{-(E_c - E_v)/kT} = N_c N_v e^{-E_g/kT}$$

$$\begin{aligned} \rightarrow n_i &= \sqrt{N_c N_v} e^{-E_g/2kT} \\ &= 2(m_n^* m_p^*)^{3/4} \left(\frac{kT}{2\pi\hbar^2} \right)^{3/2} e^{-E_g/2kT} \\ &\equiv K T^{3/2} e^{-E_g/2kT} \end{aligned}$$



$T (^{\circ}\text{C})$	$n_i (\text{cm}^{-3})$
25	8.1×10^9
35	1.7×10^{10}
45	3.5×10^{10}
55	6.9×10^{10}
65	1.3×10^{11}
75	2.3×10^{11}

Temperature dependence of n_i

$$n = N_c e^{-(E_c - E_F)/kT}, \quad p = N_v e^{-(E_F - E_v)/kT}.$$

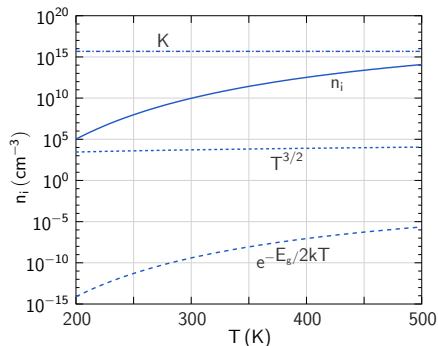
When $E_F = E_i$, $n = p = n_i$, i.e.,

$$n = n_i = N_c e^{-(E_c - E_i)/kT}, \quad p = n_i = N_v e^{-(E_i - E_v)/kT}$$

$$\rightarrow np = n_i^2 = N_c N_v e^{-(E_c - E_v)/kT} = N_c N_v e^{-E_g/kT}$$

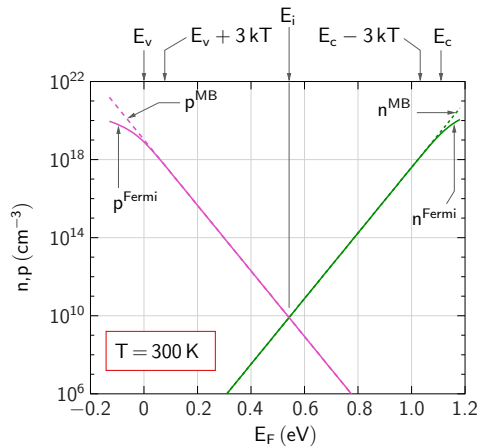
$$\begin{aligned} \rightarrow n_i &= \sqrt{N_c N_v} e^{-E_g/2kT} \\ &= 2 (m_n^* m_p^*)^{3/4} \left(\frac{kT}{2\pi\hbar^2} \right)^{3/2} e^{-E_g/2kT} \\ &\equiv K T^{3/2} e^{-E_g/2kT} \end{aligned}$$

For silicon, near room temperature, n_i nearly doubles with every 10°C rise in temperature.



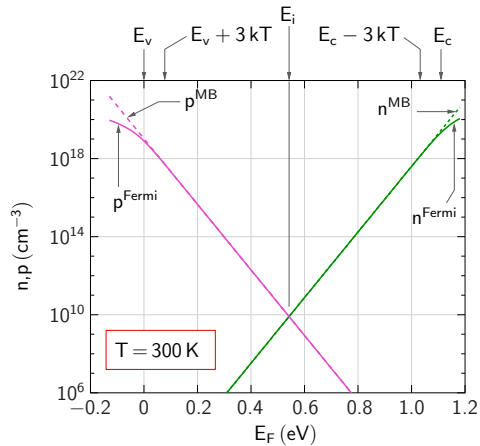
$T (^{\circ}\text{C})$	$n_i (\text{cm}^{-3})$
25	8.1×10^9
35	1.7×10^{10}
45	3.5×10^{10}
55	6.9×10^{10}
65	1.3×10^{11}
75	2.3×10^{11}

How to obtain E_F



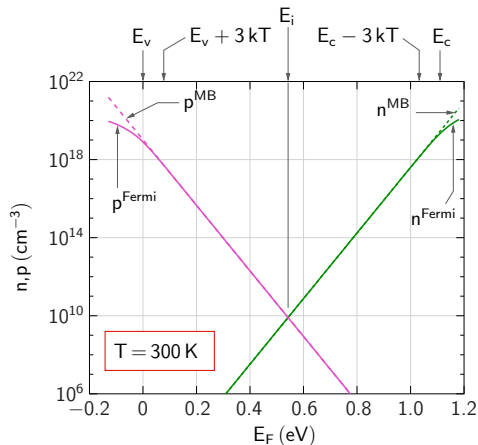
How to obtain E_F

- * So far, we have assumed a certain E_F (with respect to E_c and E_v) and obtained n and p .



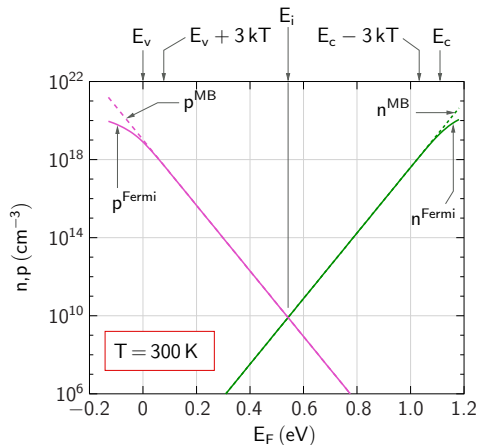
How to obtain E_F

- * So far, we have assumed a certain E_F (with respect to E_c and E_v) and obtained n and p .
- * In practice, we only have information such as N_c , N_v , E_g , T , and doping densities (N_a and N_d).

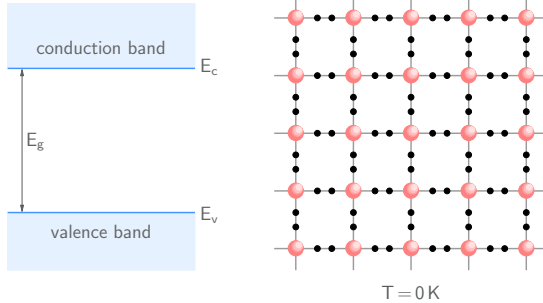


How to obtain E_F

- * So far, we have assumed a certain E_F (with respect to E_c and E_v) and obtained n and p .
- * In practice, we only have information such as N_c , N_v , E_g , T , and doping densities (N_a and N_d).
- * We now want to consider the reverse problem of finding E_F (and n , p), given the above data.

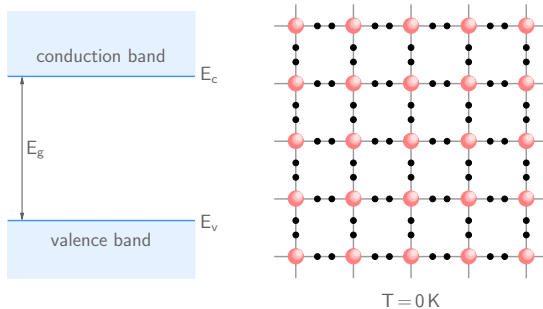


Charge considerations in equilibrium: intrinsic semiconductor



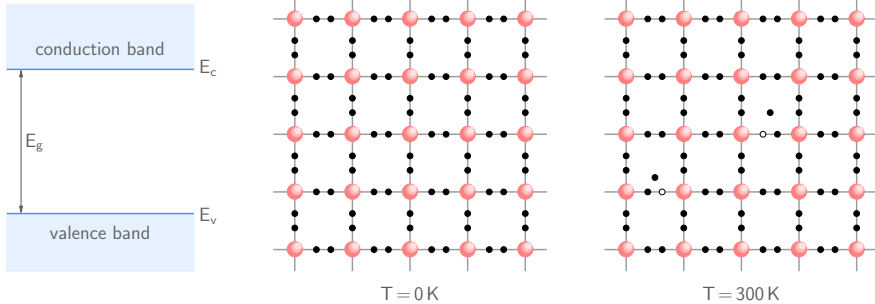
- * At 0 K, the positive charge due to the atomic cores balances the negative charge due to valence electrons.

Charge considerations in equilibrium: intrinsic semiconductor



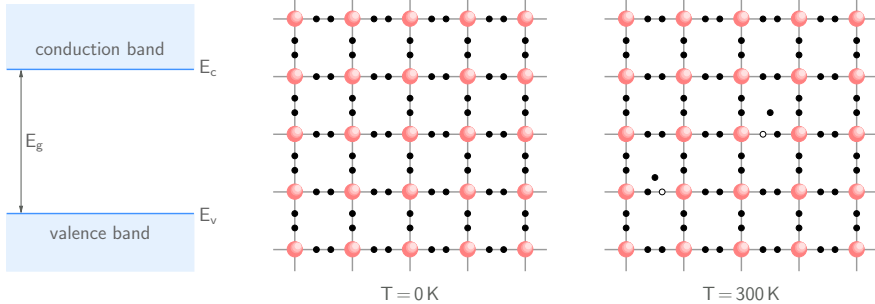
- * At 0 K, the positive charge due to the atomic cores balances the negative charge due to valence electrons.
- * As temperature increases, some of the valence electrons become free, i.e., they enter the conduction band, leaving behind positively charged holes in the valence band.

Charge considerations in equilibrium: intrinsic semiconductor



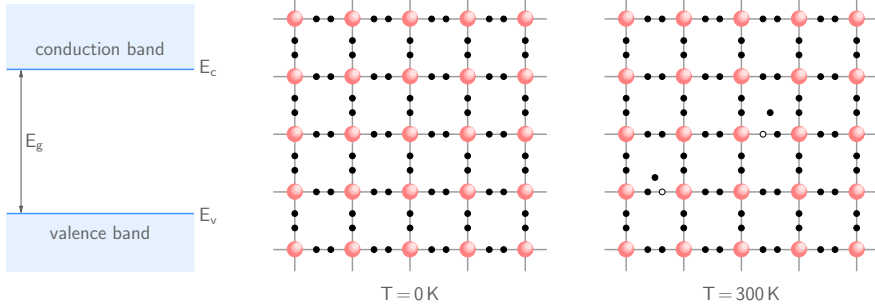
- * At 0 K, the positive charge due to the atomic cores balances the negative charge due to valence electrons.
- * As temperature increases, some of the valence electrons become free, i.e., they enter the conduction band, leaving behind positively charged holes in the valence band.

Charge considerations in equilibrium: intrinsic semiconductor



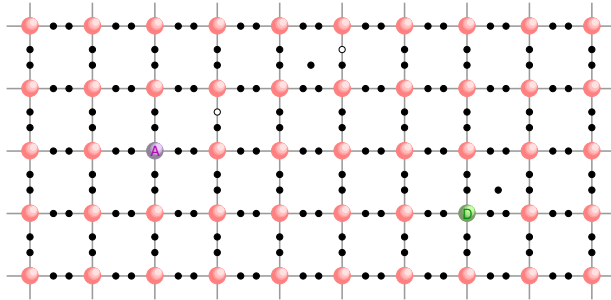
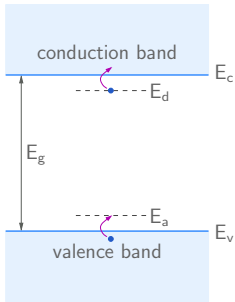
- * At 0 K, the positive charge due to the atomic cores balances the negative charge due to valence electrons.
- * As temperature increases, some of the valence electrons become free, i.e., they enter the conduction band, leaving behind positively charged holes in the valence band.
- * The number of electrons in the conduction band is equal to the number of holes in the valence band.

Charge considerations in equilibrium: intrinsic semiconductor

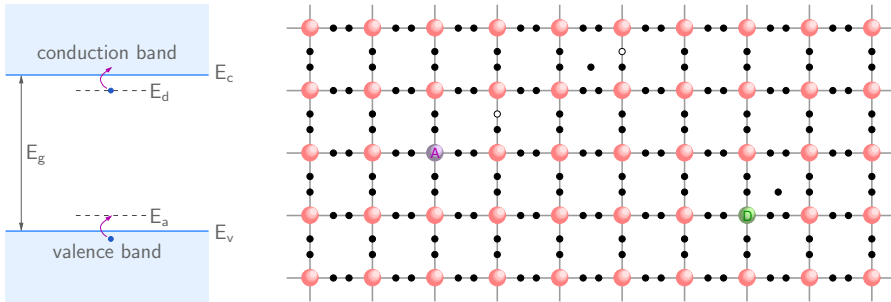


- * At 0 K, the positive charge due to the atomic cores balances the negative charge due to valence electrons.
- * As temperature increases, some of the valence electrons become free, i.e., they enter the conduction band, leaving behind positively charged holes in the valence band.
- * The number of electrons in the conduction band is equal to the number of holes in the valence band.
- * Also, their densities must be equal since the electrostatic potential is constant (no electric field) $\rightarrow n = p$.

Charge considerations in equilibrium: doped semiconductor

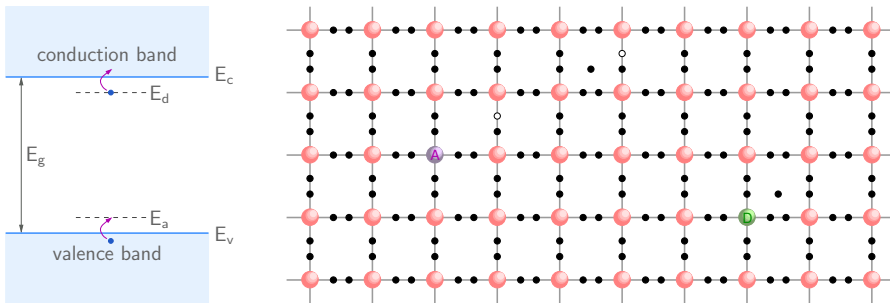


Charge considerations in equilibrium: doped semiconductor



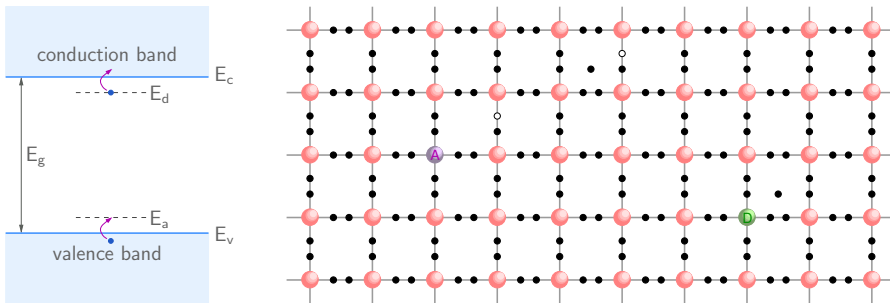
* When there are donor or acceptor atoms in the lattice, we have the following charged species.

Charge considerations in equilibrium: doped semiconductor



- * When there are donor or acceptor atoms in the lattice, we have the following charged species.
 - electrons in the conduction band (density n)

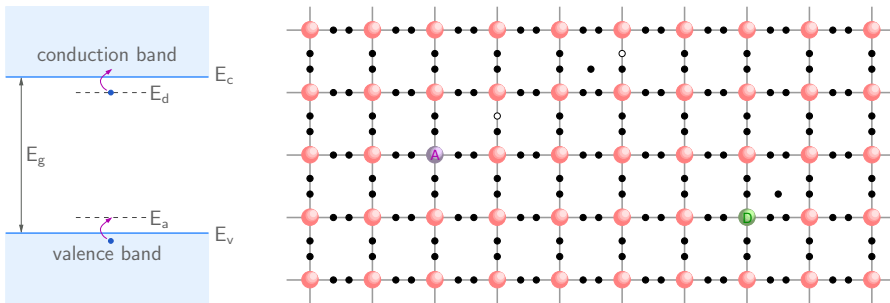
Charge considerations in equilibrium: doped semiconductor



* When there are donor or acceptor atoms in the lattice, we have the following charged species.

- electrons in the conduction band (density n)
- holes in the valence band (density p)

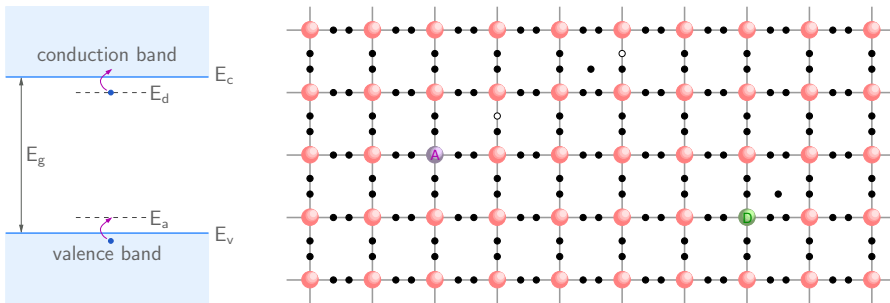
Charge considerations in equilibrium: doped semiconductor



* When there are donor or acceptor atoms in the lattice, we have the following charged species.

- electrons in the conduction band (density n)
- holes in the valence band (density p)
- ionised donor atoms (density N_d^+)

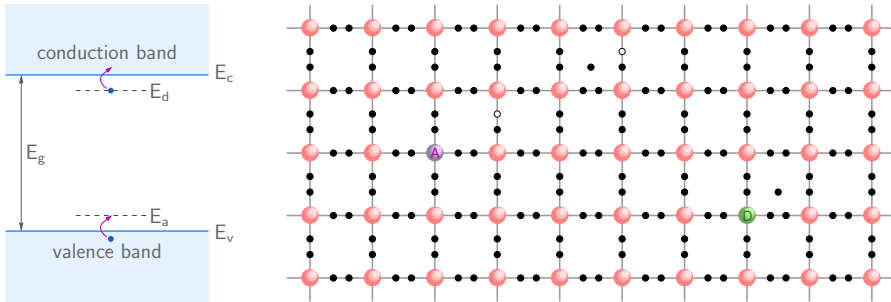
Charge considerations in equilibrium: doped semiconductor



* When there are donor or acceptor atoms in the lattice, we have the following charged species.

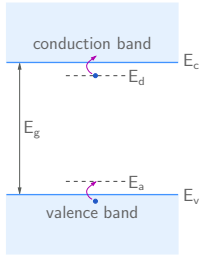
- electrons in the conduction band (density n)
- holes in the valence band (density p)
- ionised donor atoms (density N_d^+)
- ionised acceptor atoms (density N_a^-)

Charge considerations in equilibrium: doped semiconductor

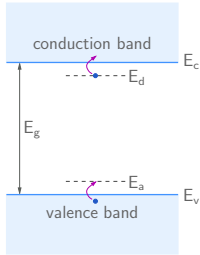


- * When there are donor or acceptor atoms in the lattice, we have the following charged species.
 - electrons in the conduction band (density n)
 - holes in the valence band (density p)
 - ionised donor atoms (density N_d^+)
 - ionised acceptor atoms (density N_a^-)
- * If the doping densities (N_a or N_d or both) are uniform in space, charge neutrality in equilibrium requires
$$-qn + qp + qN_d^+ - qN_a^- = 0 \rightarrow n + N_a^- = p + N_d^+.$$

Charge considerations in equilibrium

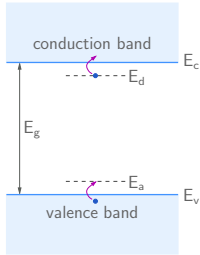


Charge considerations in equilibrium



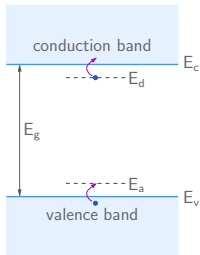
- * Let the donor density be N_d . Some of the donor atoms donate their electrons and acquire a net positive charge; the others remain neutral. $\rightarrow N_d = N_d^+ + N_d^0$.

Charge considerations in equilibrium



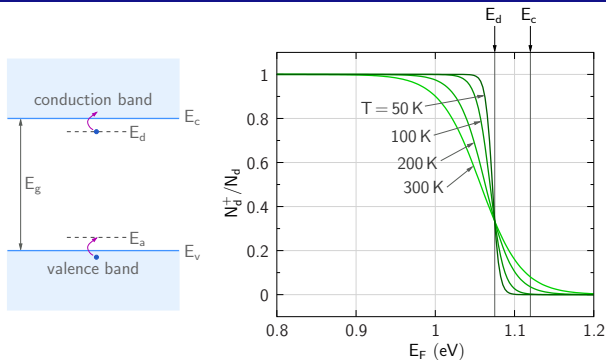
- * Let the donor density be N_d . Some of the donor atoms donate their electrons and acquire a net positive charge; the others remain neutral. $\rightarrow N_d = N_d^+ + N_d^0$.
- * Similarly, $N_a = N_a^- + N_a^0$.

Charge considerations in equilibrium



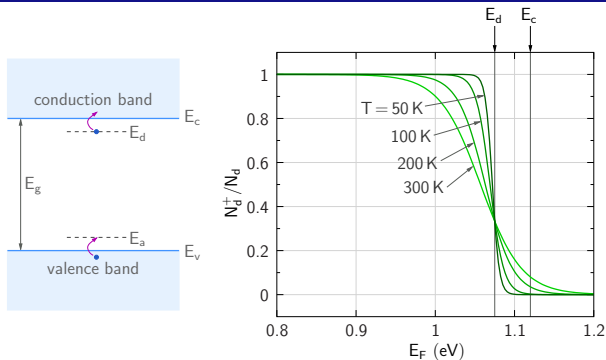
- * Let the donor density be N_d . Some of the donor atoms donate their electrons and acquire a net positive charge; the others remain neutral. $\rightarrow N_d = N_d^+ + N_d^0$.
- * Similarly, $N_a = N_a^- + N_a^0$.
- * The ratios N_d^+/N_d and N_a^-/N_a are given by $\frac{N_d^+}{N_d} = \frac{1}{1 + 2 e^{(E_F - E_d)/kT}}$, $\frac{N_a^-}{N_a} = \frac{1}{1 + 4 e^{(E_a - E_F)/kT}}$.

Charge considerations in equilibrium



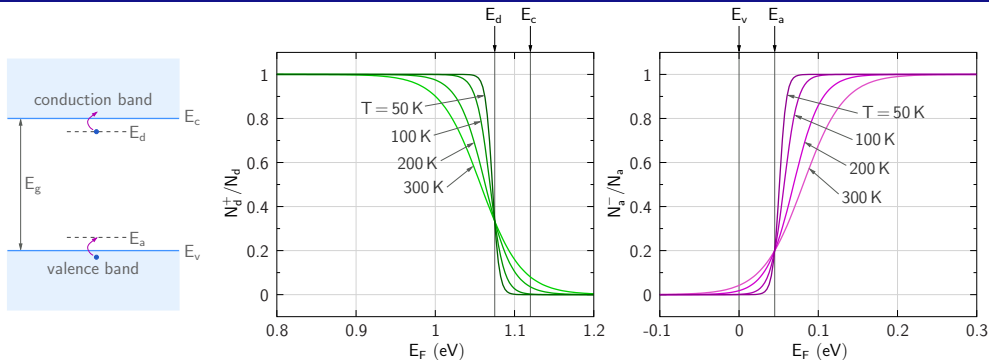
- * Let the donor density be N_d . Some of the donor atoms donate their electrons and acquire a net positive charge; the others remain neutral. $\rightarrow N_d = N_d^+ + N_d^0$.
- * Similarly, $N_a = N_a^- + N_a^0$.
- * The ratios N_d^+/N_d and N_a^-/N_a are given by $\frac{N_d^+}{N_d} = \frac{1}{1 + 2 e^{(E_F - E_d)/kT}}$, $\frac{N_a^-}{N_a} = \frac{1}{1 + 4 e^{(E_a - E_F)/kT}}$.

Charge considerations in equilibrium



- * Let the donor density be N_d . Some of the donor atoms donate their electrons and acquire a net positive charge; the others remain neutral. $\rightarrow N_d = N_d^+ + N_d^0$.
- * Similarly, $N_a = N_a^- + N_a^0$.
- * The ratios N_d^+/N_d and N_a^-/N_a are given by $\frac{N_d^+}{N_d} = \frac{1}{1 + 2 e^{(E_F - E_d)/kT}}$, $\frac{N_a^-}{N_a} = \frac{1}{1 + 4 e^{(E_a - E_F)/kT}}$.
- * $N_d^+/N_d \rightarrow 1$ if E_F is sufficiently below E_d .

Charge considerations in equilibrium



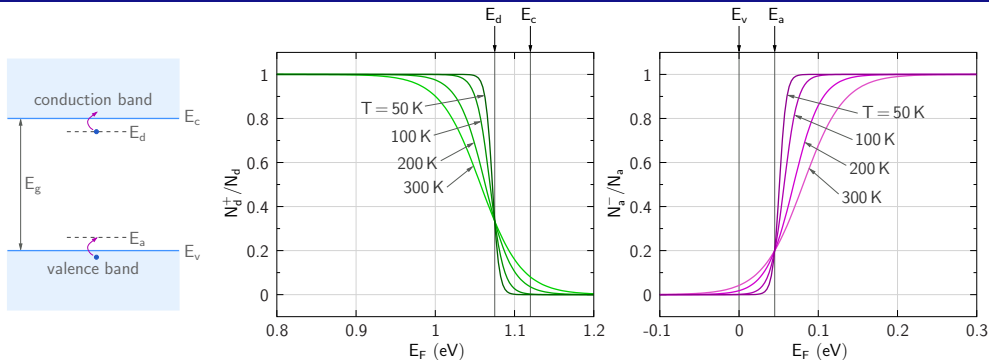
* Let the donor density be N_d . Some of the donor atoms donate their electrons and acquire a net positive charge; the others remain neutral. $\rightarrow N_d = N_d^+ + N_d^0$.

* Similarly, $N_a = N_a^- + N_a^0$.

* The ratios N_d^+/N_d and N_a^-/N_a are given by $\frac{N_d^+}{N_d} = \frac{1}{1 + 2 e^{(E_F - E_d)/kT}}$, $\frac{N_a^-}{N_a} = \frac{1}{1 + 4 e^{(E_a - E_F)/kT}}$.

* $N_d^+/N_d \rightarrow 1$ if E_F is sufficiently below E_d .

Charge considerations in equilibrium



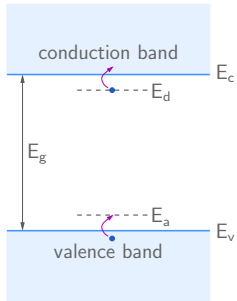
* Let the donor density be N_d . Some of the donor atoms donate their electrons and acquire a net positive charge; the others remain neutral. $\rightarrow N_d = N_d^+ + N_d^0$.

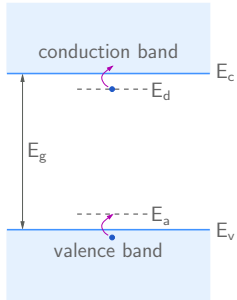
* Similarly, $N_a = N_a^- + N_a^0$.

* The ratios N_d^+/N_d and N_a^-/N_a are given by $\frac{N_d^+}{N_d} = \frac{1}{1 + 2 e^{(E_F - E_d)/kT}}$, $\frac{N_a^-}{N_a} = \frac{1}{1 + 4 e^{(E_a - E_F)/kT}}$.

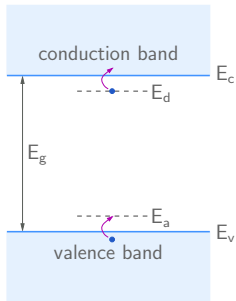
* $N_d^+/N_d \rightarrow 1$ if E_F is sufficiently below E_d .

* $N_a^-/N_a \rightarrow 1$ if E_F is sufficiently above E_a .



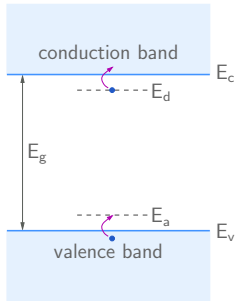


$$* \quad n + N_a^- = p + N_d^+.$$



$$* \quad n + N_a^- = p + N_d^+$$

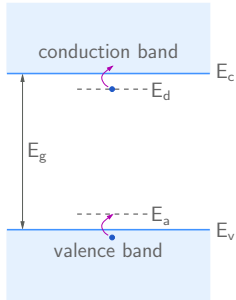
$$* \quad N_c e^{-(E_c - E_F)/kT} + \frac{N_a}{1 + 4 e^{(E_a - E_F)/kT}} = N_v e^{-(E_F - E_v)/kT} + \frac{N_d}{1 + 2 e^{(E_F - E_d)/kT}}$$



- * $n + N_a^- = p + N_d^+$.

- *
$$N_c e^{-(E_c - E_F)/kT} + \frac{N_a}{1 + 4 e^{(E_a - E_F)/kT}} = N_v e^{-(E_F - E_v)/kT} + \frac{N_d}{1 + 2 e^{(E_F - E_d)/kT}}.$$

- * We can take E_v as a reference $\rightarrow E_v = 0, E_c = E_g$.

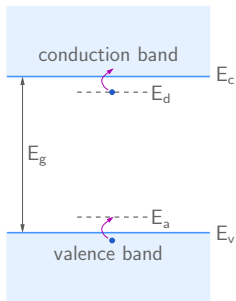


- * $n + N_a^- = p + N_d^+$.

- *
$$N_c e^{-(E_c - E_F)/kT} + \frac{N_a}{1 + 4 e^{(E_a - E_F)/kT}} = N_v e^{-(E_F - E_v)/kT} + \frac{N_d}{1 + 2 e^{(E_F - E_d)/kT}}.$$

- * We can take E_v as a reference $\rightarrow E_v = 0, E_c = E_g$.

- * This is a nonlinear equation in E_F and must be solved iteratively.



$$* \quad n + N_a^- = p + N_d^+.$$

$$* \quad N_c e^{-(E_c - E_F)/kT} + \frac{N_a}{1 + 4 e^{(E_a - E_F)/kT}} = N_v e^{-(E_F - E_v)/kT} + \frac{N_d}{1 + 2 e^{(E_F - E_d)/kT}}.$$

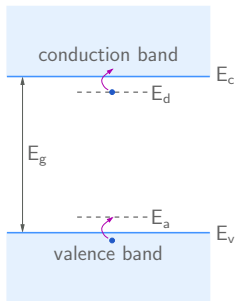
* We can take E_v as a reference $\rightarrow E_v = 0, E_c = E_g$.

* This is a nonlinear equation in E_F and must be solved iteratively.

* Note that E_g depends on the temperature. For silicon,

$$E_g(T) = E_g(0) - \alpha T^2 / (\beta + T),$$

with $E_g(0) = 1.17$ eV, $\alpha = 4.73 \times 10^{-4}$ eV/K, and $\beta = 636$ K.



$$* \quad n + N_a^- = p + N_d^+.$$

$$* \quad N_c e^{-(E_c - E_F)/kT} + \frac{N_a}{1 + 4 e^{(E_a - E_F)/kT}} = N_v e^{-(E_F - E_v)/kT} + \frac{N_d}{1 + 2 e^{(E_F - E_d)/kT}}.$$

* We can take E_v as a reference $\rightarrow E_v = 0, E_c = E_g$.

* This is a nonlinear equation in E_F and must be solved iteratively.

* Note that E_g depends on the temperature. For silicon,

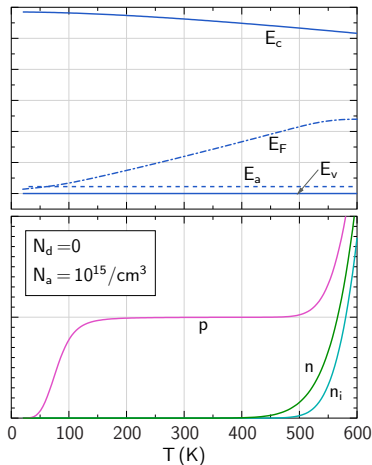
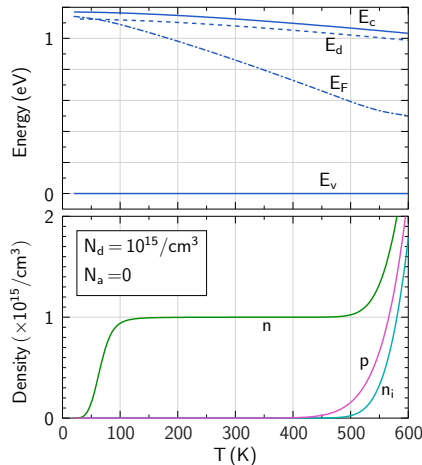
$$E_g(T) = E_g(0) - \alpha T^2 / (\beta + T),$$

with $E_g(0) = 1.17$ eV, $\alpha = 4.73 \times 10^{-4}$ eV/K, and $\beta = 636$ K.

* Let us look at the results obtained for a few representative values of N_d and N_a , with $E_c - E_d = 45$ meV, $E_a - E_v = 45$ meV.

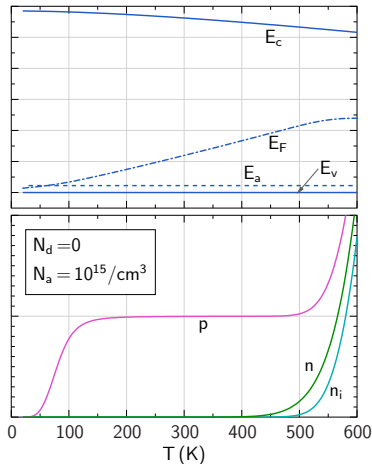
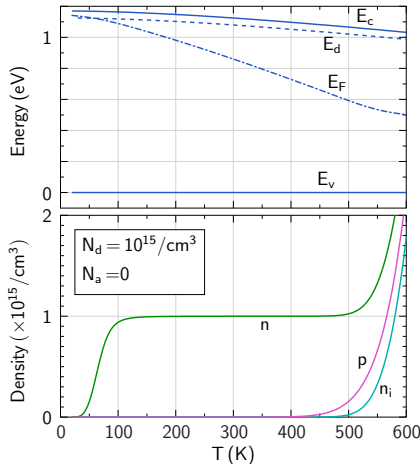
n and p in equilibrium

- * With $N_d = 10^{15} \text{ cm}^{-3}$ and $N_a = 0$,
 - At room temperature (300 K),
 $n \approx N_d$, and $p \ll n$.



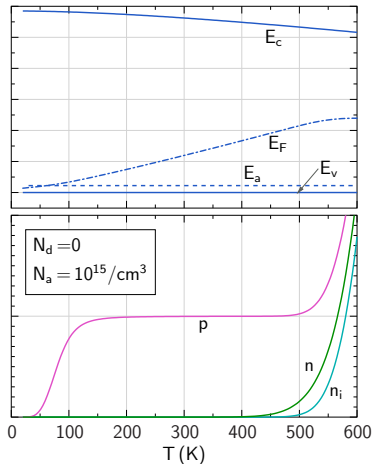
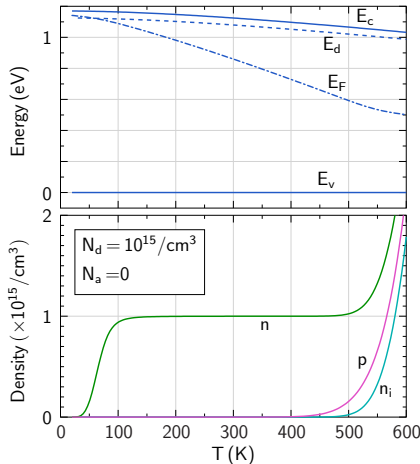
n and p in equilibrium

- * With $N_d = 10^{15} \text{ cm}^{-3}$ and $N_a = 0$,
 - At room temperature (300 K), $n \approx N_d$, and $p \ll n$.
 - Since $N_d^+ + p = n$, we have $N_d^+ \approx N_d$, i.e., complete ionisation of the donor atoms.



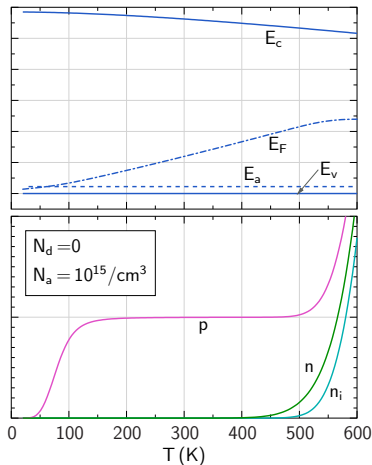
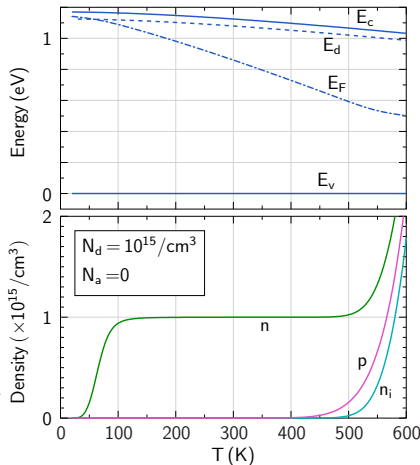
n and p in equilibrium

- * With $N_d = 10^{15} \text{ cm}^{-3}$ and $N_a = 0$,
 - At room temperature (300 K), $n \approx N_d$, and $p \ll n$.
 - Since $N_d^+ + p = n$, we have $N_d^+ \approx N_d$, i.e., complete ionisation of the donor atoms.
- * With $N_a = 10^{15} \text{ cm}^{-3}$ and $N_d = 0$,
 - At room temperature (300 K), $p \approx N_a$, and $n \ll p$.



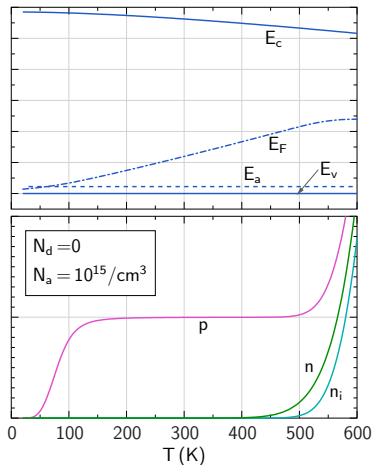
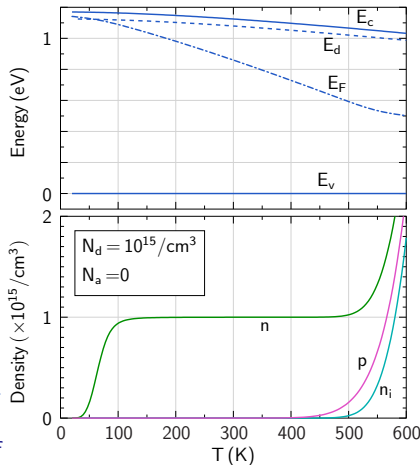
n and p in equilibrium

- * With $N_d = 10^{15} \text{ cm}^{-3}$ and $N_a = 0$,
 - At room temperature (300 K), $n \approx N_d$, and $p \ll n$.
 - Since $N_d^+ + p = n$, we have $N_d^+ \approx N_d$, i.e., complete ionisation of the donor atoms.
- * With $N_a = 10^{15} \text{ cm}^{-3}$ and $N_d = 0$,
 - At room temperature (300 K), $p \approx N_a$, and $n \ll p$.
 - Since $N_a^- + n = p$, we have $N_a^- \approx N_a$, i.e., complete ionisation of the acceptor atoms.



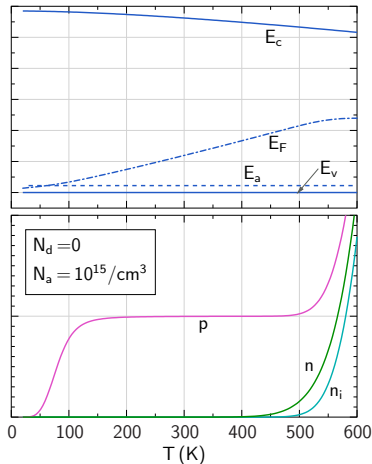
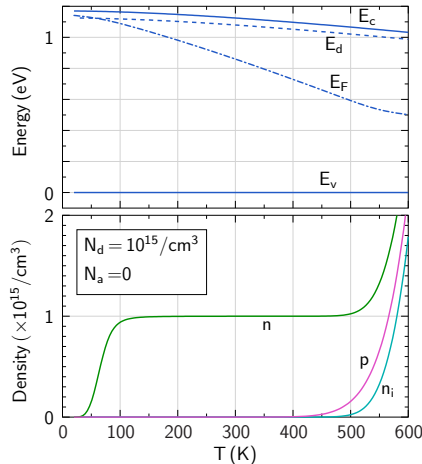
n and p in equilibrium

- * With $N_d = 10^{15} \text{ cm}^{-3}$ and $N_a = 0$,
 - At room temperature (300 K), $n \approx N_d$, and $p \ll n$.
 - Since $N_d^+ + p = n$, we have $N_d^+ \approx N_d$, i.e., complete ionisation of the donor atoms.
- * With $N_a = 10^{15} \text{ cm}^{-3}$ and $N_d = 0$,
 - At room temperature (300 K), $p \approx N_a$, and $n \ll p$.
 - Since $N_a^- + n = p$, we have $N_a^- \approx N_a$, i.e., complete ionisation of the acceptor atoms.
- * In fact, the condition of complete ionisation is valid over a wide range of temperatures, called the “extrinsic” temperature region.



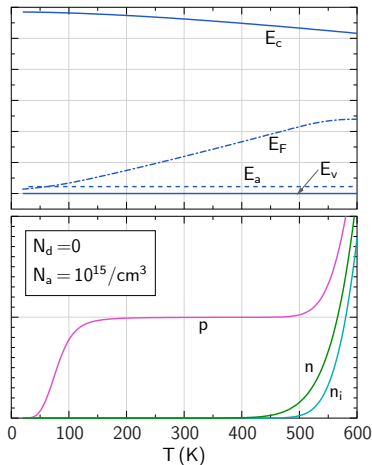
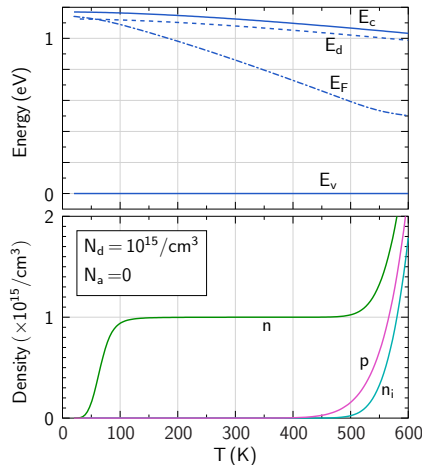
n and p in equilibrium

- * Note that one of the carrier densities is much larger than the other (in the extrinsic region). The more abundant carrier is called the “majority carrier,” and the other carrier is called the “minority carrier.”



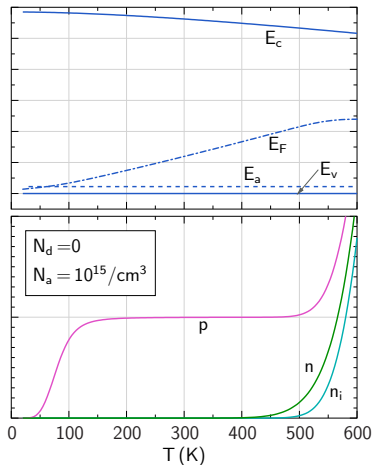
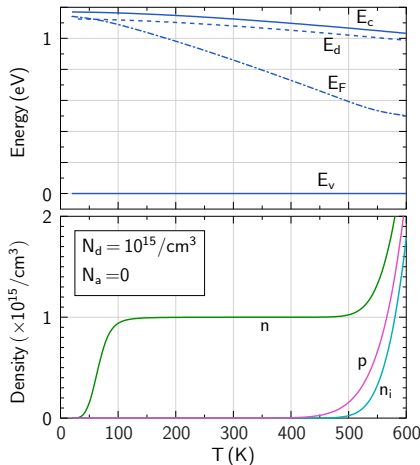
n and p in equilibrium

- * Note that one of the carrier densities is much larger than the other (in the extrinsic region). The more abundant carrier is called the “majority carrier,” and the other carrier is called the “minority carrier.”
- * For $N_d = 10^{15} \text{ cm}^{-3}$ and $N_a = 0$, electrons are the majority carriers. For $N_a = 10^{15} \text{ cm}^{-3}$ and $N_d = 0$, holes are the majority carriers.



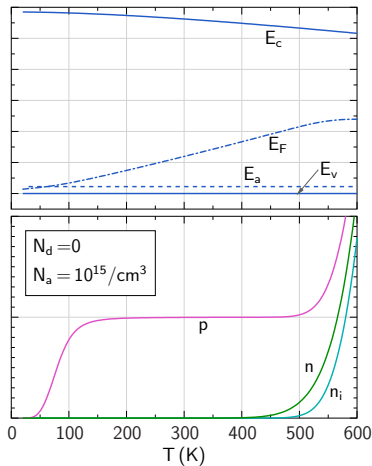
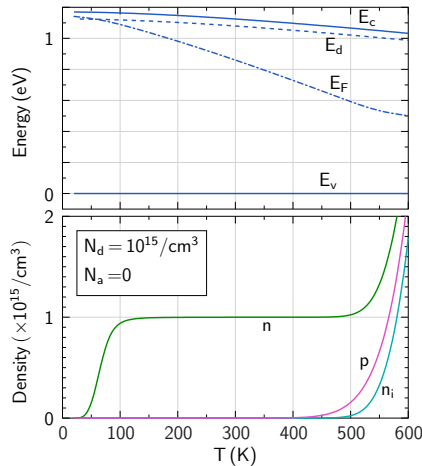
n and p in equilibrium

- * Note that one of the carrier densities is much larger than the other (in the extrinsic region). The more abundant carrier is called the “majority carrier,” and the other carrier is called the “minority carrier.”
- * For $N_d = 10^{15} \text{ cm}^{-3}$ and $N_a = 0$, electrons are the majority carriers. For $N_a = 10^{15} \text{ cm}^{-3}$ and $N_d = 0$, holes are the majority carriers.
- * A semiconductor with electrons as majority carriers is called an n -type semiconductor. A semiconductor with holes as majority carriers is called a p -type semiconductor.



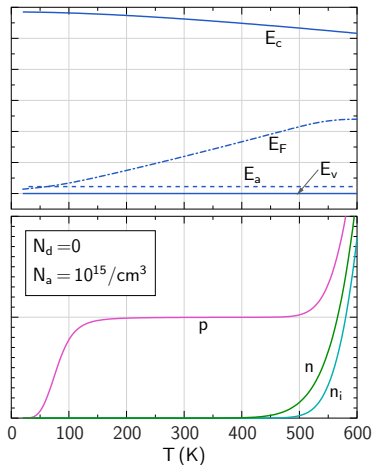
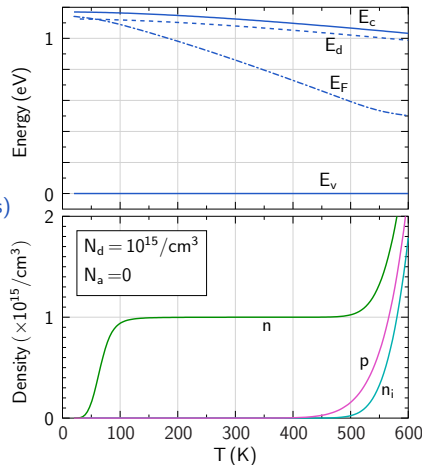
n and p in equilibrium

- * At low temperatures, a significant fraction of impurity atoms remains neutral, causing a reduction in n or p .



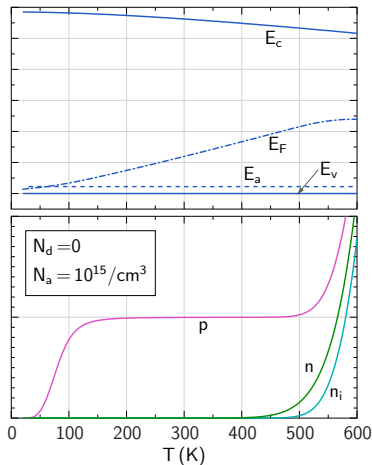
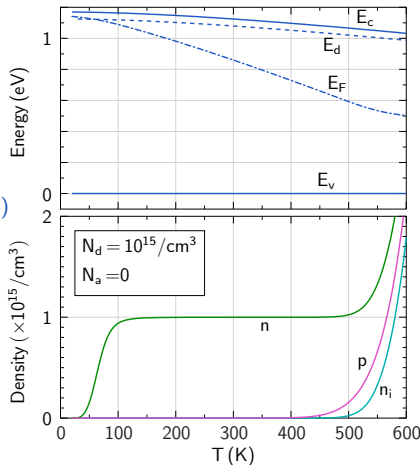
n and p in equilibrium

- * At low temperatures, a significant fraction of impurity atoms remains neutral, causing a reduction in n or p .
- * The carriers remain “frozen” at the impurity sites, i.e., electrons remain bound to donors, and holes (vacancies) remain bound to acceptors.



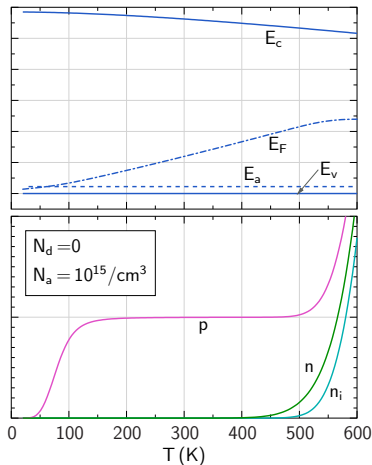
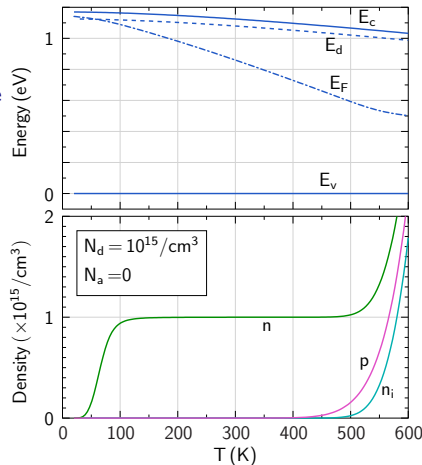
n and p in equilibrium

- * At low temperatures, a significant fraction of impurity atoms remains neutral, causing a reduction in n or p .
- * The carriers remain “frozen” at the impurity sites, i.e., electrons remain bound to donors, and holes (vacancies) remain bound to acceptors.
- * This effect is called the carrier “freeze-out” effect, and it can be a limiting factor in low-temperature operation of semiconductor devices.



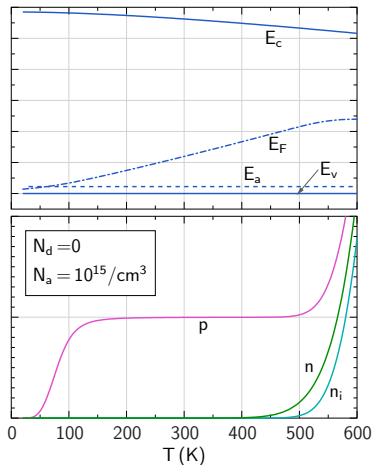
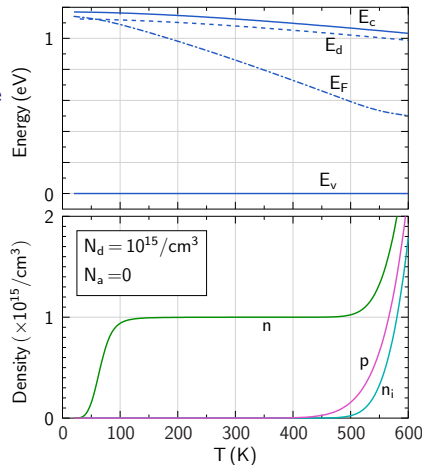
n and p in equilibrium

- * At high temperatures, the intrinsic carrier concentration n_i becomes large and starts dominating.



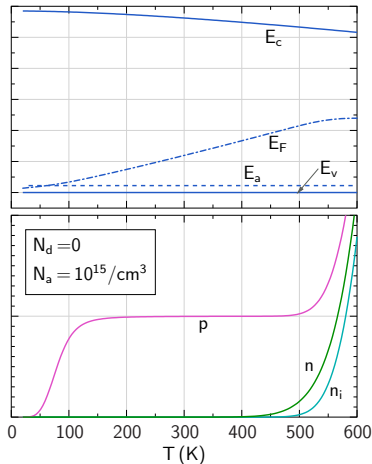
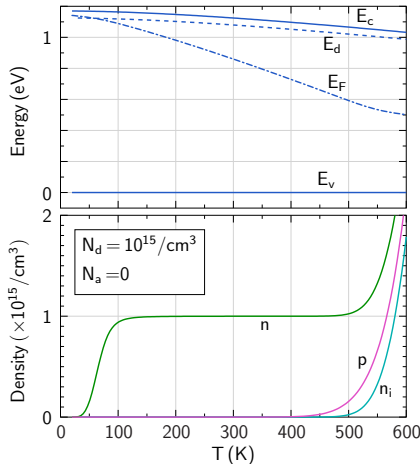
n and p in equilibrium

- * At high temperatures, the intrinsic carrier concentration n_i becomes large and starts dominating.
- * As a result, n and p become comparable (and larger than N_d or N_a).



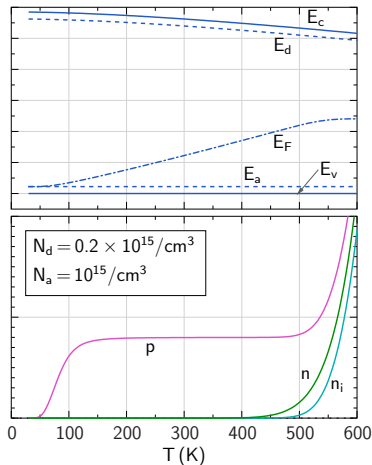
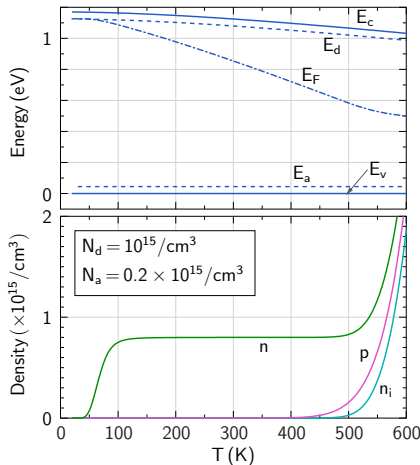
n and p in equilibrium

- * At high temperatures, the intrinsic carrier concentration n_i becomes large and starts dominating.
- * As a result, n and p become comparable (and larger than N_d or N_a).
- * This region is called the “intrinsic region,” and it must be avoided for a semiconductor device to work as intended.



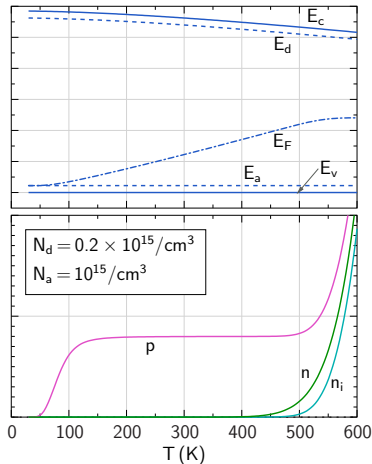
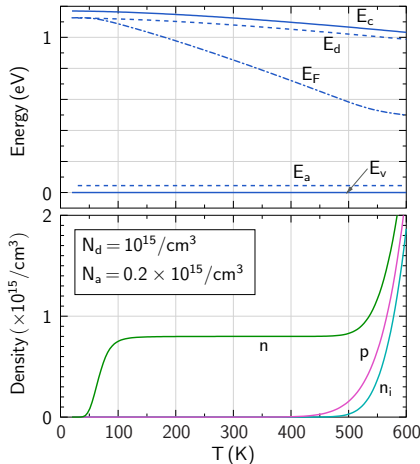
n and p in equilibrium: compensated semiconductor

- * If both types of dopants are present, the dopant with the larger density dominates.



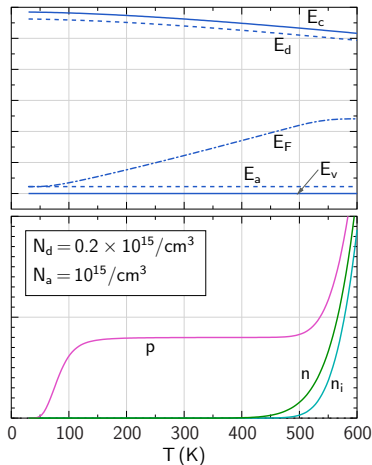
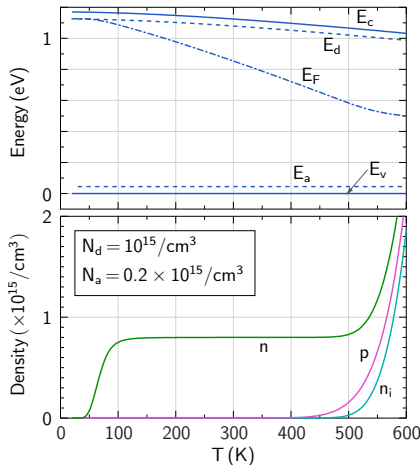
n and p in equilibrium: compensated semiconductor

- * If both types of dopants are present, the dopant with the larger density dominates.
- * If $N_d \gg N_a$, the semiconductor is n -type, and $n = N_d - N_a$ (in the extrinsic temperature range).



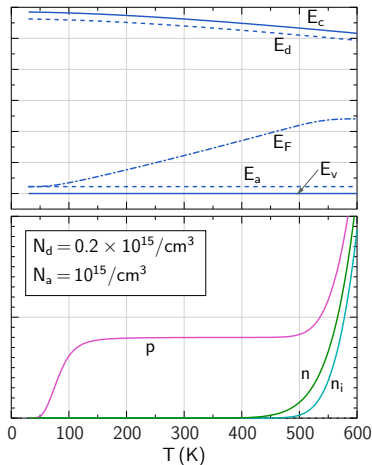
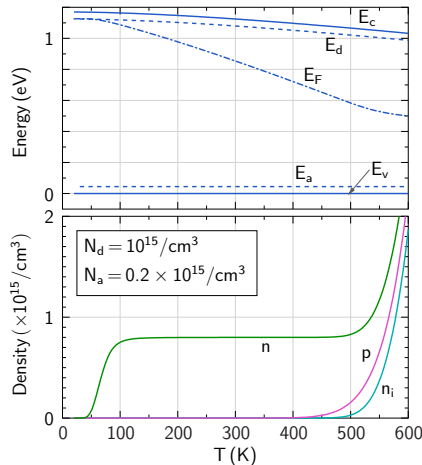
n and p in equilibrium: compensated semiconductor

- * If both types of dopants are present, the dopant with the larger density dominates.
- * If $N_d \gg N_a$, the semiconductor is n -type, and $n = N_d - N_a$ (in the extrinsic temperature range).
- * If $N_a \gg N_d$, the semiconductor is p -type, and $p = N_a - N_d$ (in the extrinsic temperature range).



n and p in equilibrium: compensated semiconductor

- * If both types of dopants are present, the dopant with the larger density dominates.
- * If $N_d \gg N_a$, the semiconductor is n -type, and $n = N_d - N_a$ (in the extrinsic temperature range).
- * If $N_a \gg N_d$, the semiconductor is p -type, and $p = N_a - N_d$ (in the extrinsic temperature range).
- * A semiconductor with both types of dopants is called a “compensated” semiconductor.



- * We have seen that $N_d^+ \approx N_d$ and $N_a^- \approx N_a$ at room temperature. This makes the computation of n and p much easier.

- * We have seen that $N_d^+ \approx N_d$ and $N_a^- \approx N_a$ at room temperature. This makes the computation of n and p much easier.
- * Charge neutrality $\rightarrow n + N_a^- = p + N_d^+ \rightarrow n + N_a \approx p + N_d$.

- * We have seen that $N_d^+ \approx N_d$ and $N_a^- \approx N_a$ at room temperature. This makes the computation of n and p much easier.
- * Charge neutrality $\rightarrow n + N_a^- = p + N_d^+ \rightarrow n + N_a \approx p + N_d$.
- * Also, assuming non-degenerate conditions, we have

$$\begin{aligned}np &= N_c e^{-(E_c - E_F)/kT} \times N_v e^{-(E_F - E_v)/kT} \\&= N_c N_v e^{-(E_c - E_v)/kT} \\&= N_c N_v e^{-E_g/kT} \\&= n_i^2(T).\end{aligned}$$

- * We have seen that $N_d^+ \approx N_d$ and $N_a^- \approx N_a$ at room temperature. This makes the computation of n and p much easier.
- * Charge neutrality $\rightarrow n + N_a^- = p + N_d^+ \rightarrow n + N_a \approx p + N_d$.
- * Also, assuming non-degenerate conditions, we have

$$\begin{aligned}np &= N_c e^{-(E_c - E_F)/kT} \times N_v e^{-(E_F - E_v)/kT} \\&= N_c N_v e^{-(E_c - E_v)/kT} \\&= N_c N_v e^{-E_g/kT} \\&= n_i^2(T).\end{aligned}$$

- * The above two equations can be solved to obtain n and p .

Computation of n and p at room temperature in equilibrium: example

In a silicon sample with $N_d = 5 \times 10^{16} \text{ cm}^{-3}$, find the equilibrium electron and hole concentrations at $T = 300 \text{ K}$ ($n_i = 10^{10} \text{ cm}^{-3}$ at 300 K).

Computation of n and p at room temperature in equilibrium: example

In a silicon sample with $N_d = 5 \times 10^{16} \text{ cm}^{-3}$, find the equilibrium electron and hole concentrations at $T = 300 \text{ K}$ ($n_i = 10^{10} \text{ cm}^{-3}$ at 300 K).

Solution: $n + N_a^- = p + N_d^+ \rightarrow n \approx p + N_d$

Computation of n and p at room temperature in equilibrium: example

In a silicon sample with $N_d = 5 \times 10^{16} \text{ cm}^{-3}$, find the equilibrium electron and hole concentrations at $T = 300 \text{ K}$ ($n_i = 10^{10} \text{ cm}^{-3}$ at 300 K).

Solution: $n + N_a^- = p + N_d^+ \rightarrow n \approx p + N_d$

Using $np = n_i^2$, i.e., $p = \frac{n_i^2}{n}$, we get

$$n = \frac{n_i^2}{n} + N_d \rightarrow n^2 - nN_d - n_i^2 = 0 \rightarrow n = \frac{N_d \pm \sqrt{N_d^2 + 4n_i^2}}{2}.$$

Computation of n and p at room temperature in equilibrium: example

In a silicon sample with $N_d = 5 \times 10^{16} \text{ cm}^{-3}$, find the equilibrium electron and hole concentrations at $T = 300 \text{ K}$ ($n_i = 10^{10} \text{ cm}^{-3}$ at 300 K).

Solution: $n + N_a^- = p + N_d^+ \rightarrow n \approx p + N_d$

Using $np = n_i^2$, i.e., $p = \frac{n_i^2}{n}$, we get

$$n = \frac{n_i^2}{n} + N_d \rightarrow n^2 - nN_d - n_i^2 = 0 \rightarrow n = \frac{N_d \pm \sqrt{N_d^2 + 4n_i^2}}{2}.$$

+ sign gives a physically meaningful result, viz.,

$$n \approx N_d = 5 \times 10^{16} \text{ cm}^{-3}, \quad p = \frac{n_i^2}{n} = \frac{10^{20}}{5 \times 10^{16}} = 2 \times 10^3 \text{ cm}^{-3}.$$

Computation of n and p at room temperature in equilibrium: example

In a silicon sample with $N_d = 5 \times 10^{16} \text{ cm}^{-3}$, find the equilibrium electron and hole concentrations at $T = 300 \text{ K}$ ($n_i = 10^{10} \text{ cm}^{-3}$ at 300 K).

Solution: $n + N_a^- = p + N_d^+ \rightarrow n \approx p + N_d$

Using $np = n_i^2$, i.e., $p = \frac{n_i^2}{n}$, we get

$$n = \frac{n_i^2}{n} + N_d \rightarrow n^2 - nN_d - n_i^2 = 0 \rightarrow n = \frac{N_d \pm \sqrt{N_d^2 + 4n_i^2}}{2}.$$

+ sign gives a physically meaningful result, viz.,

$$n \approx N_d = 5 \times 10^{16} \text{ cm}^{-3}, \quad p = \frac{n_i^2}{n} = \frac{10^{20}}{5 \times 10^{16}} = 2 \times 10^3 \text{ cm}^{-3}.$$

Since $n \gg p$, this is an n -type sample.

Computation of n and p at room temperature in equilibrium: example

In a silicon sample with $N_d = 5 \times 10^{16} \text{ cm}^{-3}$, find the equilibrium electron and hole concentrations at $T = 300 \text{ K}$ ($n_i = 10^{10} \text{ cm}^{-3}$ at 300 K).

Solution: $n + N_a^- = p + N_d^+ \rightarrow n \approx p + N_d$

Using $np = n_i^2$, i.e., $p = \frac{n_i^2}{n}$, we get

$$n = \frac{n_i^2}{n} + N_d \rightarrow n^2 - nN_d - n_i^2 = 0 \rightarrow n = \frac{N_d \pm \sqrt{N_d^2 + 4n_i^2}}{2}.$$

+ sign gives a physically meaningful result, viz.,

$$n \approx N_d = 5 \times 10^{16} \text{ cm}^{-3}, \quad p = \frac{n_i^2}{n} = \frac{10^{20}}{5 \times 10^{16}} = 2 \times 10^3 \text{ cm}^{-3}.$$

Since $n \gg p$, this is an n -type sample.

Calculation of E_F : $n = N_c e^{-(E_c - E_F)/kT}$

Computation of n and p at room temperature in equilibrium: example

In a silicon sample with $N_d = 5 \times 10^{16} \text{ cm}^{-3}$, find the equilibrium electron and hole concentrations at $T = 300 \text{ K}$ ($n_i = 10^{10} \text{ cm}^{-3}$ at 300 K).

Solution: $n + N_a^- = p + N_d^+ \rightarrow n \approx p + N_d$

Using $np = n_i^2$, i.e., $p = \frac{n_i^2}{n}$, we get

$$n = \frac{n_i^2}{n} + N_d \rightarrow n^2 - nN_d - n_i^2 = 0 \rightarrow n = \frac{N_d \pm \sqrt{N_d^2 + 4n_i^2}}{2}.$$

+ sign gives a physically meaningful result, viz.,

$$n \approx N_d = 5 \times 10^{16} \text{ cm}^{-3}, \quad p = \frac{n_i^2}{n} = \frac{10^{20}}{5 \times 10^{16}} = 2 \times 10^3 \text{ cm}^{-3}.$$

Since $n \gg p$, this is an n -type sample.

Calculation of E_F : $n = N_c e^{-(E_c - E_F)/kT}$

$$\rightarrow E_c - E_F = kT \log \frac{N_c}{n} = (0.0259 \text{ eV}) \log \frac{2.8 \times 10^{19}}{5 \times 10^{16}} = 0.1636 \text{ eV}.$$

Computation of n and p at room temperature in equilibrium: example

In a silicon sample with $N_d = 5 \times 10^{16} \text{ cm}^{-3}$, find the equilibrium electron and hole concentrations at $T = 300 \text{ K}$ ($n_i = 10^{10} \text{ cm}^{-3}$ at 300 K).

Solution: $n + N_a^- = p + N_d^+ \rightarrow n \approx p + N_d$

Using $np = n_i^2$, i.e., $p = \frac{n_i^2}{n}$, we get

$$n = \frac{n_i^2}{n} + N_d \rightarrow n^2 - nN_d - n_i^2 = 0 \rightarrow n = \frac{N_d \pm \sqrt{N_d^2 + 4n_i^2}}{2}.$$

+ sign gives a physically meaningful result, viz.,

$$n \approx N_d = 5 \times 10^{16} \text{ cm}^{-3}, \quad p = \frac{n_i^2}{n} = \frac{10^{20}}{5 \times 10^{16}} = 2 \times 10^3 \text{ cm}^{-3}.$$

Since $n \gg p$, this is an n -type sample.

Calculation of E_F : $n = N_c e^{-(E_c - E_F)/kT}$

$$\rightarrow E_c - E_F = kT \log \frac{N_c}{n} = (0.0259 \text{ eV}) \log \frac{2.8 \times 10^{19}}{5 \times 10^{16}} = 0.1636 \text{ eV}.$$

(Solving the charge neutrality equation exactly gives $n = 4.9 \times 10^{16} \text{ cm}^{-3}$,

$$E_c - E_F = 0.1641 \text{ eV}.)$$

Computation of n and p at room temperature in equilibrium: example

In a silicon sample with $N_d = 5 \times 10^{16} \text{ cm}^{-3}$, find the equilibrium electron and hole concentrations at $T = 300 \text{ K}$ ($n_i = 10^{10} \text{ cm}^{-3}$ at 300 K).

Solution: $n + N_a^- = p + N_d^+ \rightarrow n \approx p + N_d$

Using $np = n_i^2$, i.e., $p = \frac{n_i^2}{n}$, we get

$$n = \frac{n_i^2}{n} + N_d \rightarrow n^2 - nN_d - n_i^2 = 0 \rightarrow n = \frac{N_d \pm \sqrt{N_d^2 + 4n_i^2}}{2}.$$

+ sign gives a physically meaningful result, viz.,

$$n \approx N_d = 5 \times 10^{16} \text{ cm}^{-3}, \quad p = \frac{n_i^2}{n} = \frac{10^{20}}{5 \times 10^{16}} = 2 \times 10^3 \text{ cm}^{-3}.$$

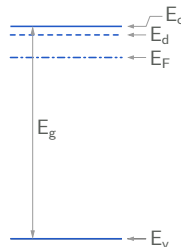
Since $n \gg p$, this is an n -type sample.

Calculation of E_F : $n = N_c e^{-(E_c - E_F)/kT}$

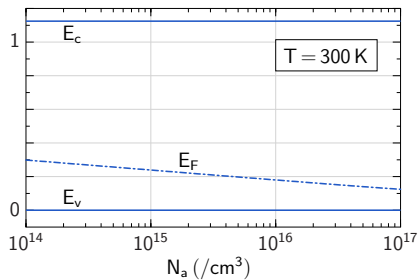
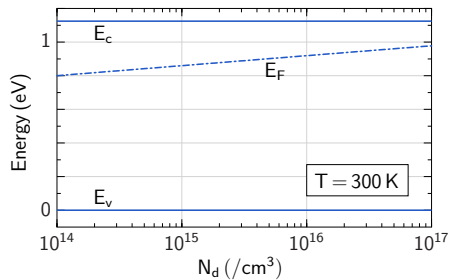
$$\rightarrow E_c - E_F = kT \log \frac{N_c}{n} = (0.0259 \text{ eV}) \log \frac{2.8 \times 10^{19}}{5 \times 10^{16}} = 0.1636 \text{ eV}.$$

(Solving the charge neutrality equation exactly gives $n = 4.9 \times 10^{16} \text{ cm}^{-3}$,

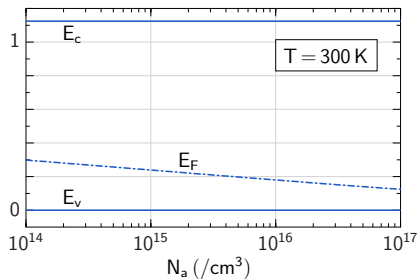
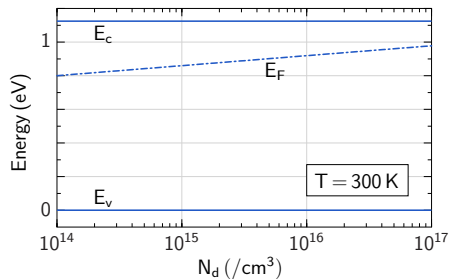
$$E_c - E_F = 0.1641 \text{ eV}.)$$



Variation of E_F with doping density (silicon, 300 K)

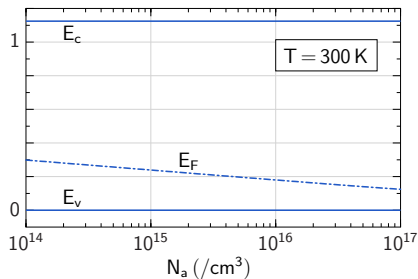
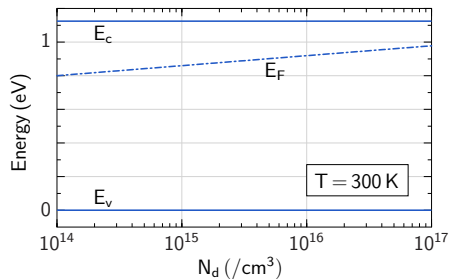


Variation of E_F with doping density (silicon, 300 K)



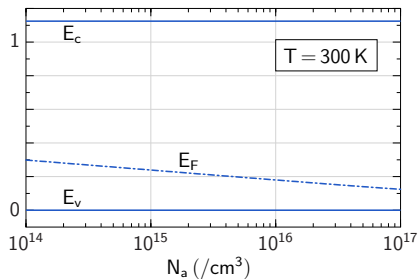
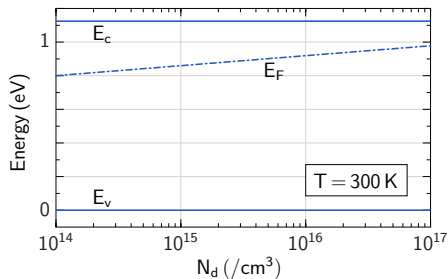
* *n*-type semiconductor: E_F gets closer to E_c as N_d is increased.

Variation of E_F with doping density (silicon, 300 K)



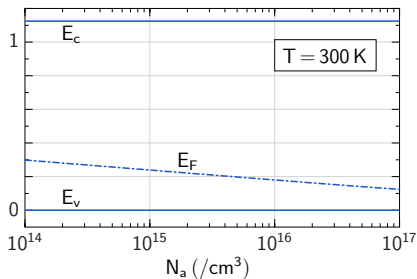
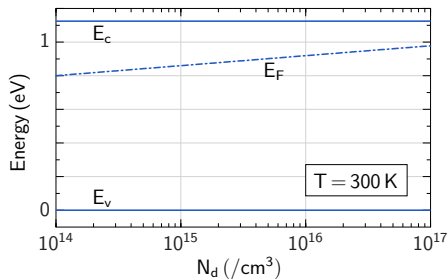
- * *n*-type semiconductor: E_F gets closer to E_c as N_d is increased.
- * *p*-type semiconductor: E_F gets closer to E_v as N_a is increased.

Variation of E_F with doping density (silicon, 300 K)



- * *n*-type semiconductor: E_F gets closer to E_c as N_d is increased.
- * *p*-type semiconductor: E_F gets closer to E_v as N_a is increased.
- * $n \approx N_d = N_c e^{-(E_c - E_F)/kT} \rightarrow E_c - E_F = kT \log \frac{N_c}{n} \approx kT (\log N_c - \log N_d)$.
 $\rightarrow (E_c - E_F)$ varies linearly with $\log N_d$.

Variation of E_F with doping density (silicon, 300 K)



- * n-type semiconductor: E_F gets closer to E_c as N_d is increased.
- * p-type semiconductor: E_F gets closer to E_v as N_a is increased.
- * $n \approx N_d = N_c e^{-(E_c - E_F)/kT} \rightarrow E_c - E_F = kT \log \frac{N_c}{n} \approx kT (\log N_c - \log N_d)$.
 $\rightarrow (E_c - E_F)$ varies linearly with $\log N_d$.
- * $p \approx N_a = N_v e^{-(E_F - E_v)/kT} \rightarrow E_F - E_v = kT \log \frac{N_v}{p} \approx kT (\log N_v - \log N_a)$.
 $\rightarrow (E_F - E_v)$ varies linearly with $\log N_a$.